



# **REDUCED GRAPHENE OXIDE FOILS FOR ION STRIPPER APPLICATIONS**

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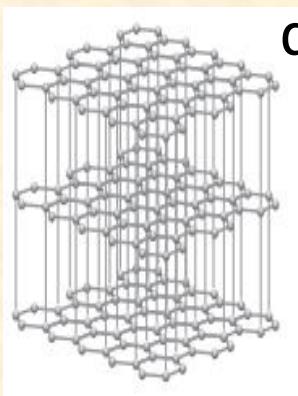
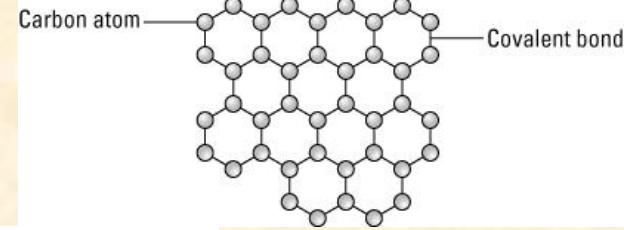
*3 CNR-IPCF, Messina, Italy*

**CHERNE 2019 -15th Workshop on European Collaboration in Higher Education on Radiological  
and Nuclear Engineering and Radiation Protection , 2-5 June 2019, Portopalo di Capo Passero**

# Outline

- + **Introduction (Graphene based materials)**
- + **Material preparation and characterization**
- + **Objectives : rGO as Ion Strippers**
- + **Preliminar measurements with rGO stripper**
- + **Future developments: Increase and optimize the measurements with rGO strippers in accelerators.**

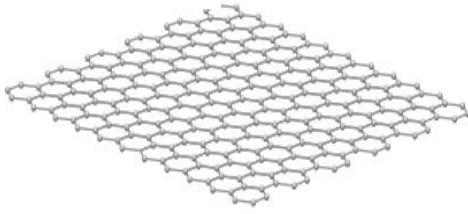
# Introduction: Graphene-based materials (C allotropic state)



$d_p = 3.4 \text{ \AA}$

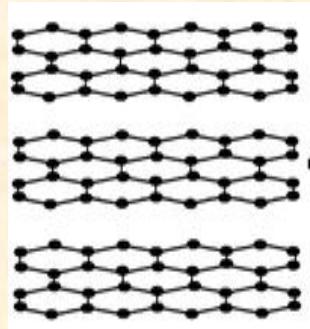
Mechanical exfoliation

(the scotch tape technique)

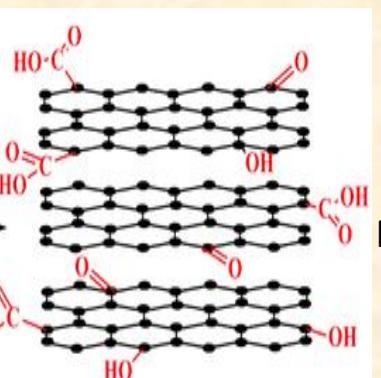


Graphene

Graphite(Gt)

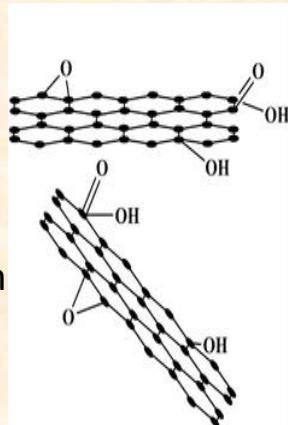


Oxidation  
(Hummers method)  
( $\text{KMnO}_4, \text{H}_2\text{SO}_4$ )



Exfoliation  
(sonication, stirring)

Mechanical exfoliation  
(Ultrasonication)



Graphene oxide(GO)

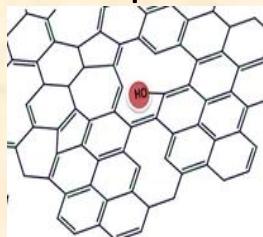


Graphite(Gt)

Graphite oxide(GtO)

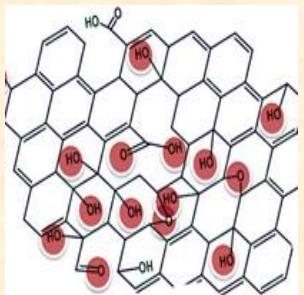
(GO platelets in water)

$\mu$ -metric platelets



Reduced  
graphene  
oxide (rGO)

Graphene  
oxide(GO)



Reduction  
(chemical, thermal, ions, laser,...)

# GO preparation as self-supported thin films

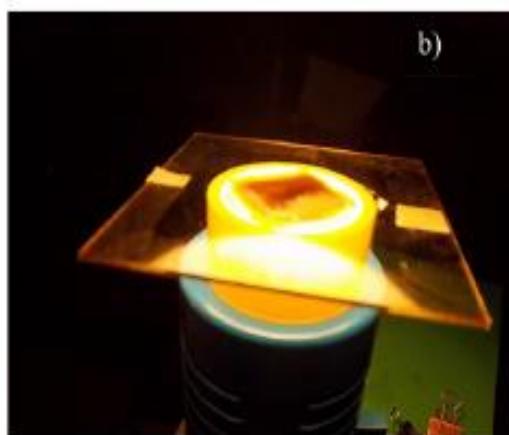
(Spin coating  
preparation film)

L. Torrisi et Al.,  
*Vacuum* 160,  
2019, 1-11

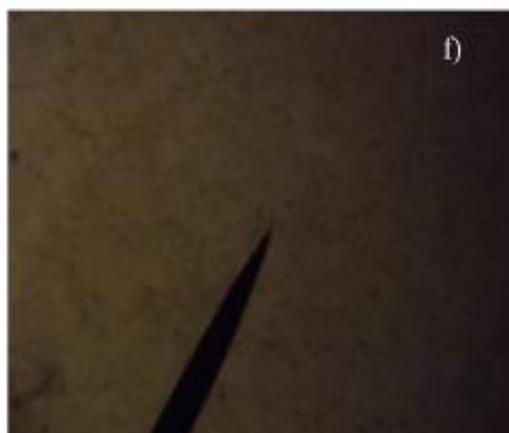


Concentrated GO solution

Diluted GO solution



$\Phi = 4 \text{ cm}$



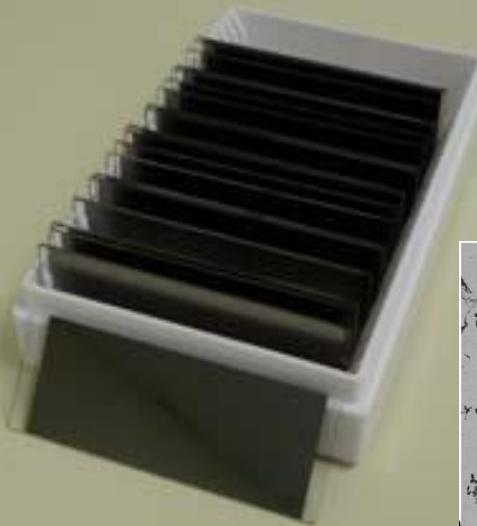
Thickness:  
 $\sim 2 \mu\text{g}/\text{cm}^2$  (10 nm)

$\sim 20 \mu\text{g}/\text{cm}^2$  (100 nm)

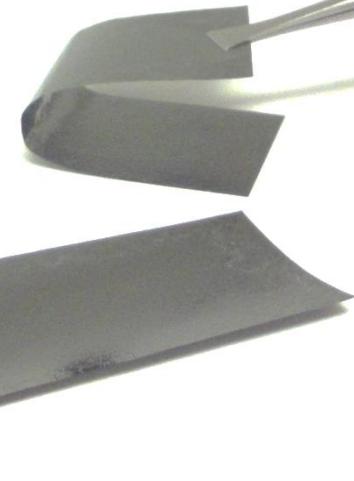
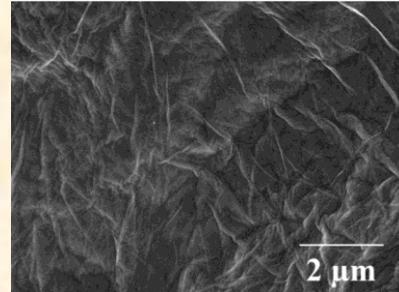
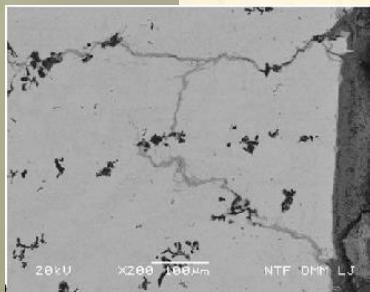
$\sim 200 \mu\text{g}/\text{cm}^2$  (1  $\mu\text{m}$ )

$\sim 2 \text{ mg}/\text{cm}^2$  (10  $\mu\text{m}$ )

Property	Graphite	Graphene	GO	rGO
In-plane thermal conductivity at RT (W/m·K)	1950-2000	1500-5300	2.9	650
Thermal conductivity along c axis at RT (W/m·K)	0.7-20		0.5	1 (RT) 10 (300°C)
Electrical conductivity (S/cm)	$2 \times 10^5 \parallel$ basal plane $3 \times 10^2 \perp$ basal plane	2000	$1.2 \times 10^{-5}$	1350
Density (g/cm <sup>3</sup> )	2.09-2.25	0.005	1.5	1.6-1.91
Young's Modulus(GPa)	11.5	1000	207.6	260
Vickers Hardness (kg/mm <sup>2</sup> )	7-11			160
Tensile Strength (MPa)	10	130		90
Melting point (°C)	3730	4237	3600	>3800
Specific Surface area (m <sup>2</sup> g <sup>-1</sup> )		2630	736	422-500
Carrier mobility (cm <sup>2</sup> V <sup>-1</sup> s <sup>-1</sup> )	>10 <sup>4</sup>	$10^3 - 2 \times 10^5$	153	0.05-372
Sheet (for graphene) Resistance (W/sq) at RT		400 (<3nm)	$10^{12}$	14000
Optical transmittance (%)	97.7	94.0	96	85
Refractive index n	2.52-2.67 at 550nm	2.0-3.0 at 550nm	1.957 at 634 nm	1.84-2 at 634 nm

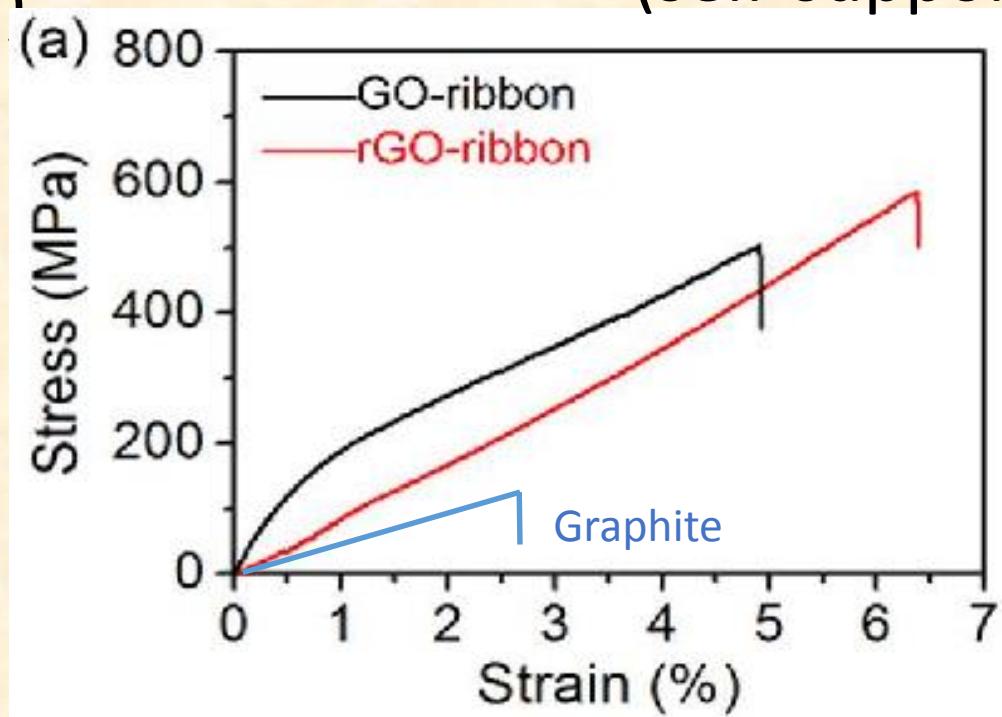


$\mu$ -cracks



## Graphite thin films (on glass substrate)

Tensile  
stress

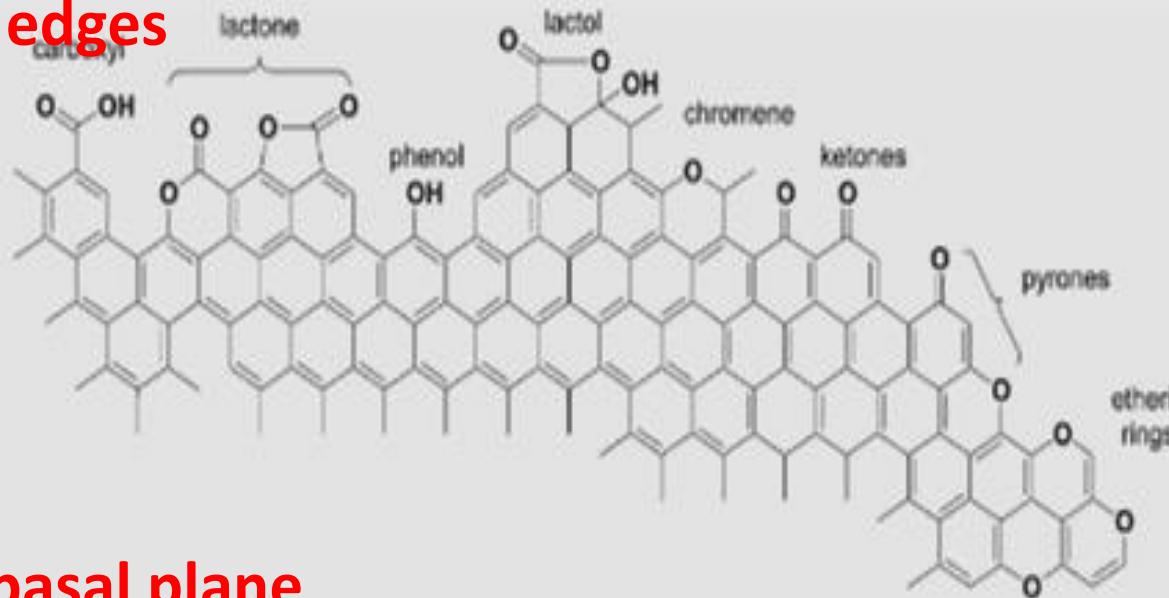


## Graphene oxide thin films (self-supported)

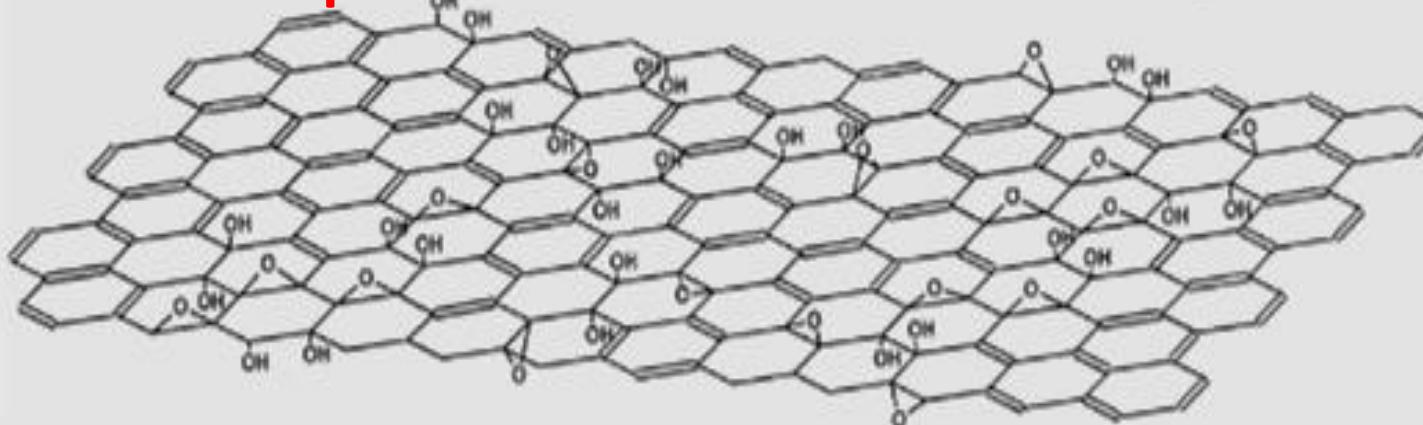


# Graphene Oxide

At the edges



At the basal plane

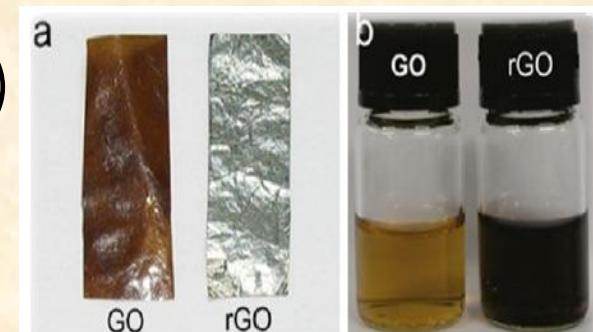


Functional groups:

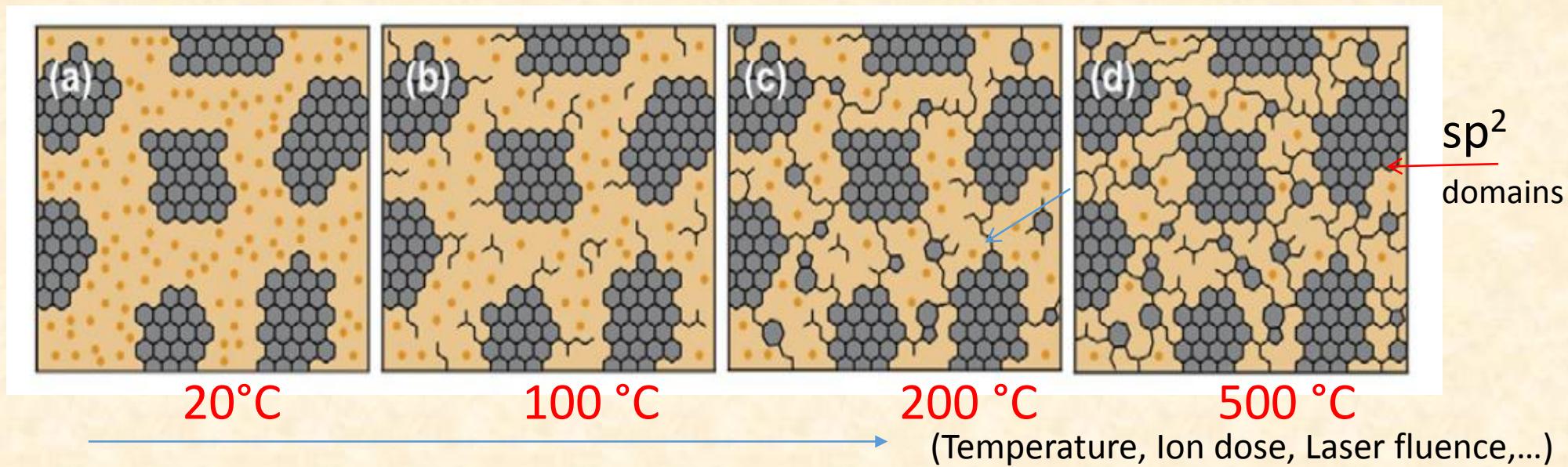
- hydroxyl (C-OH)
- epoxy (C-O-C)
- carbonyl (C=O)
- carboxyl (O-C=O)
- Presence of H<sub>2</sub> and H<sub>2</sub>O.

The GO reduction can be obtained by:

- 1) Thermal processes  
(as a function of the temperature in air, nitrogen and vacuum)
- 2) Ion beam processes  
(in vacuum as a function of the dose:  $10^{13}$ - $10^{16}$  /cm $^2$ )
- 3) Laser beam processes  
(as a function of fluence 1-100 J/cm $^2$ , wavelength, pulse duration. In air, nitrogen, in vacuum,...)
- 4) Chemical processes (Hydrazine reduction)

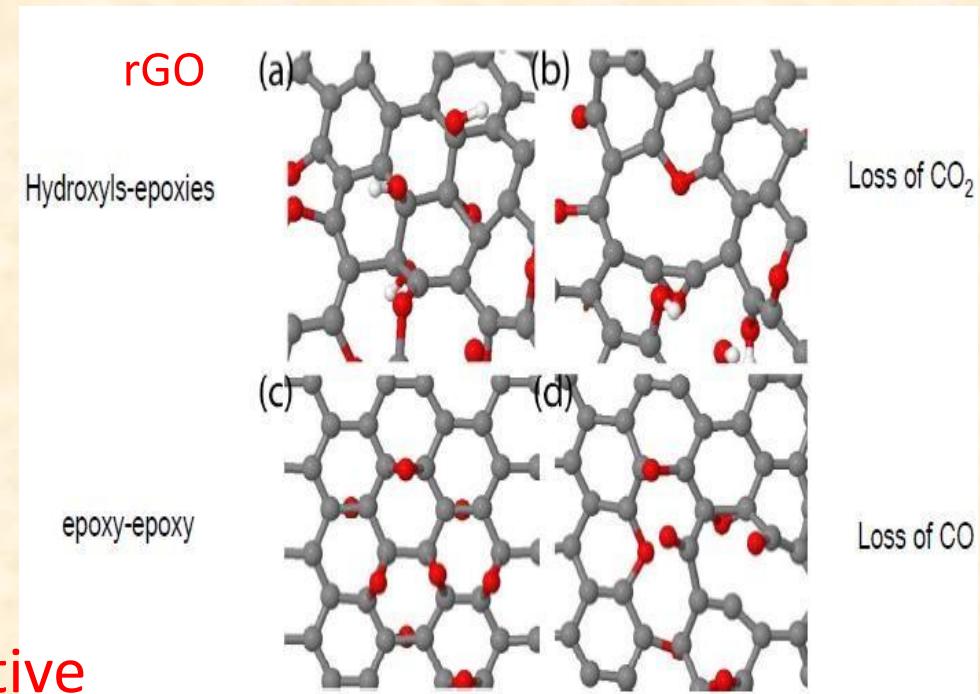


# Evolution of GO structure with reduction

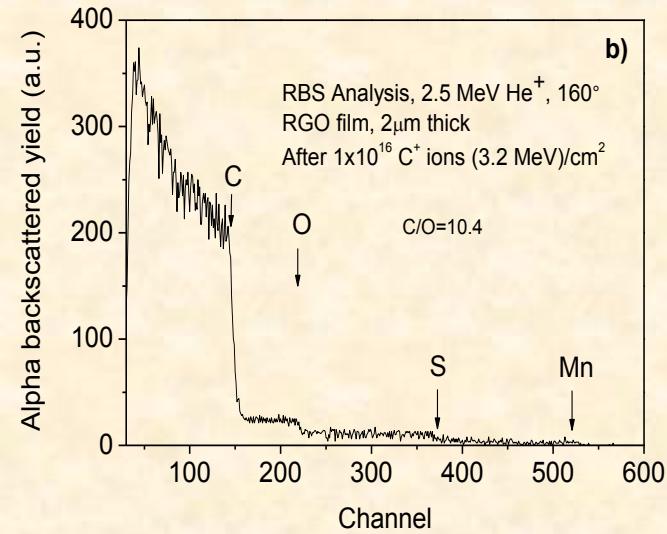
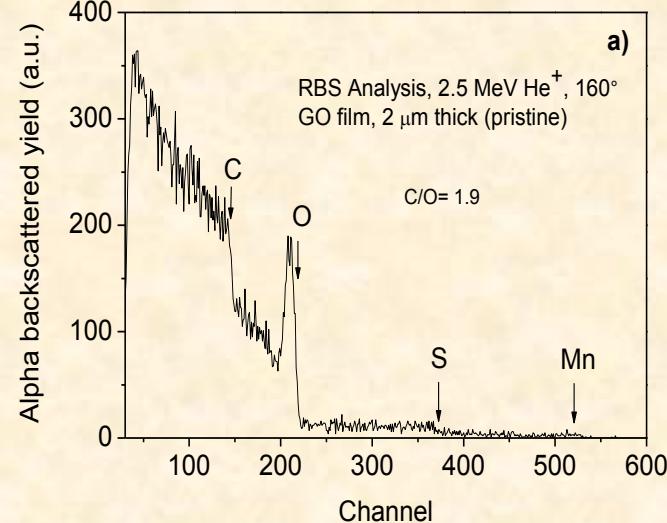


The dark grey areas represent  $\text{sp}^2$  carbon clusters and the light brown areas represent  $\text{sp}^3$  carbon bonded to oxygen groups (represented by small dots).

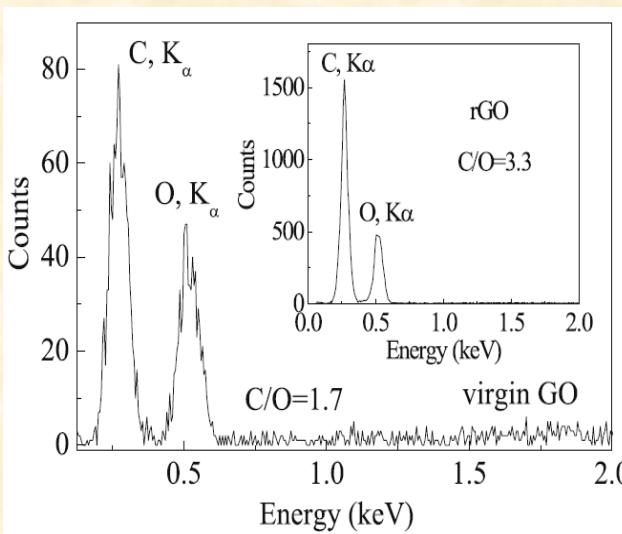
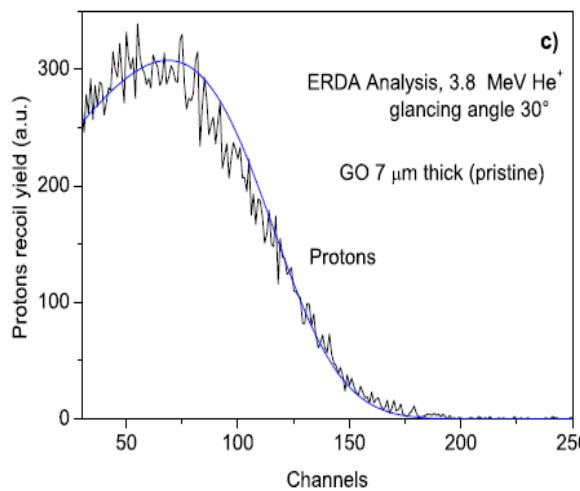
Electrically conductive



# RBS Analysis

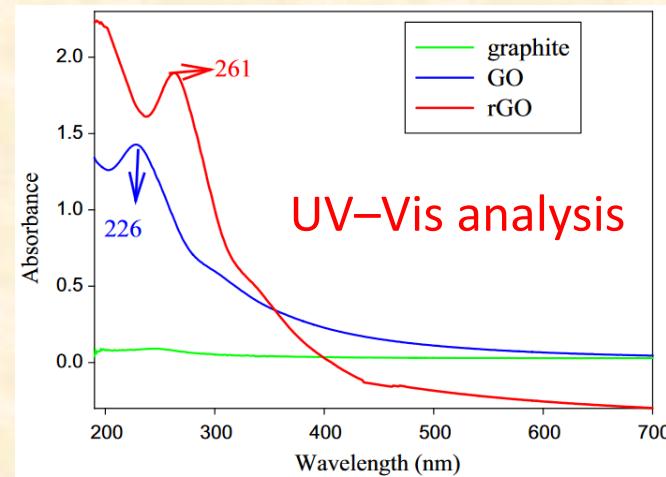
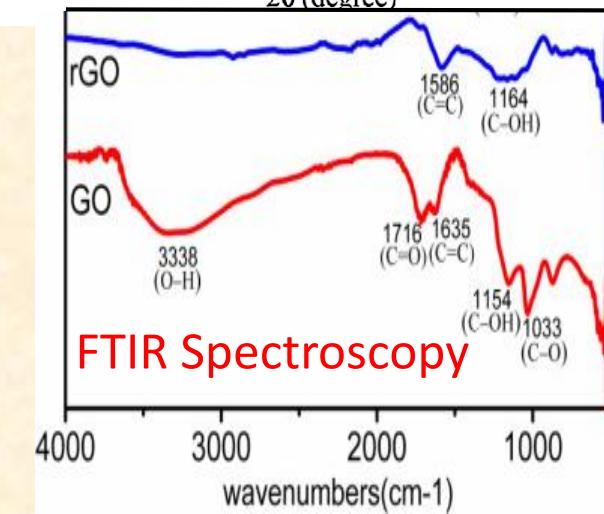
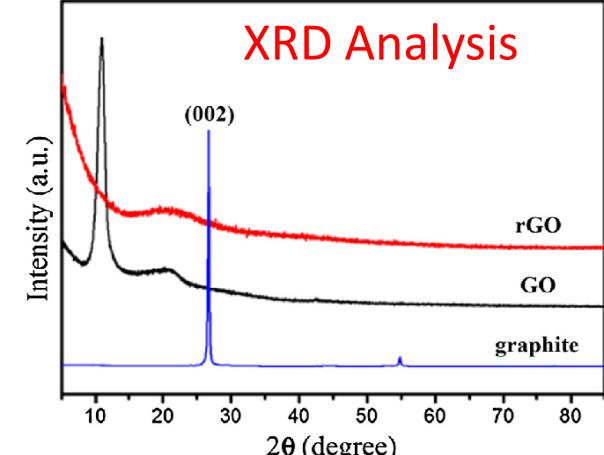


# ERDA Analysis

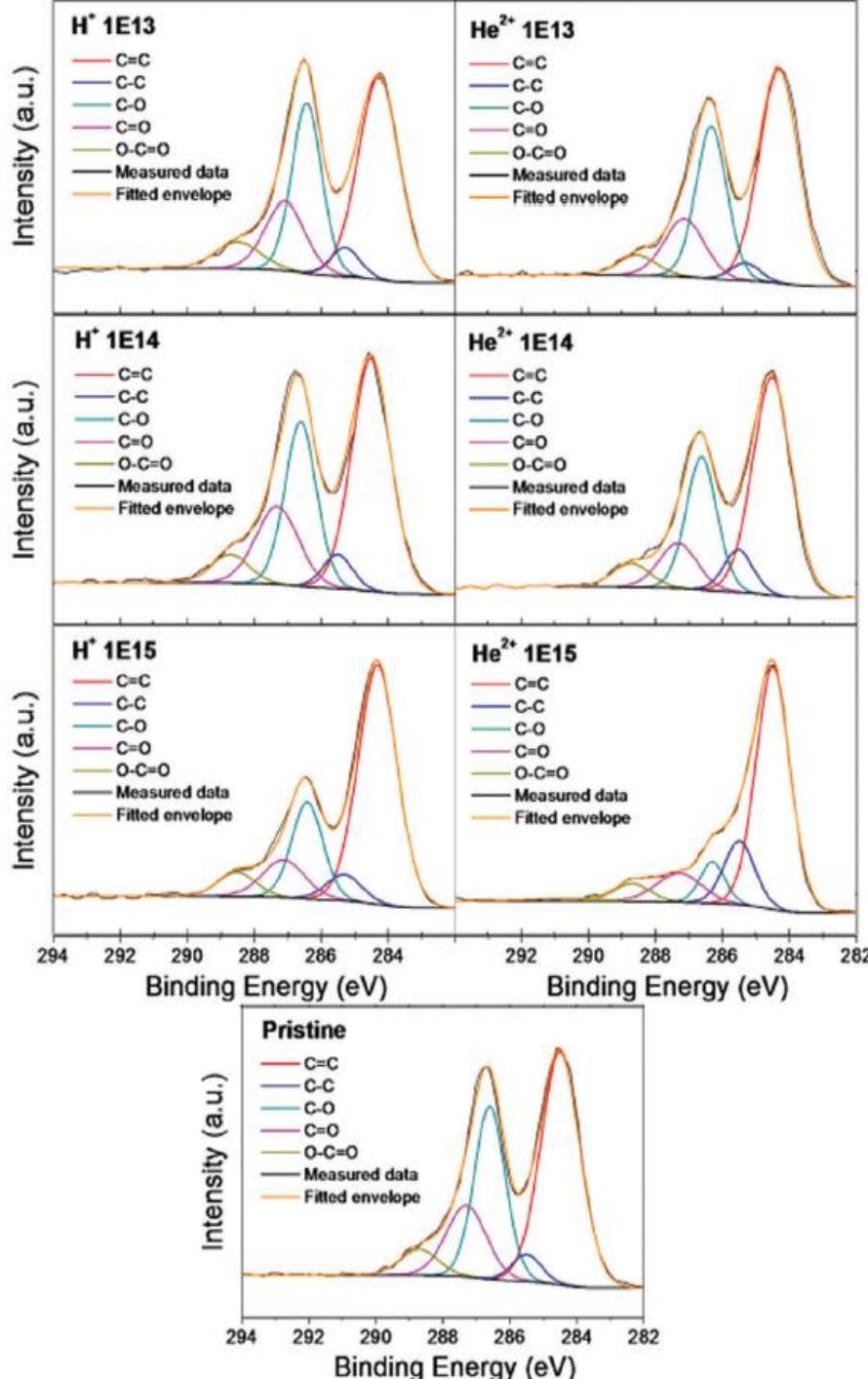


L. Silipigni et al.,  
*Vacuum* 165, 254 (2019)

# EDX Analysis

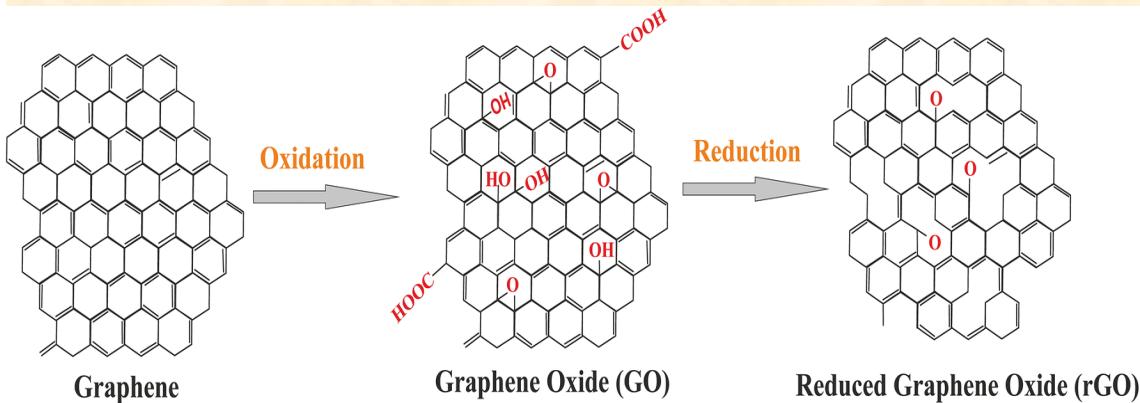


# XPS Spectroscopy



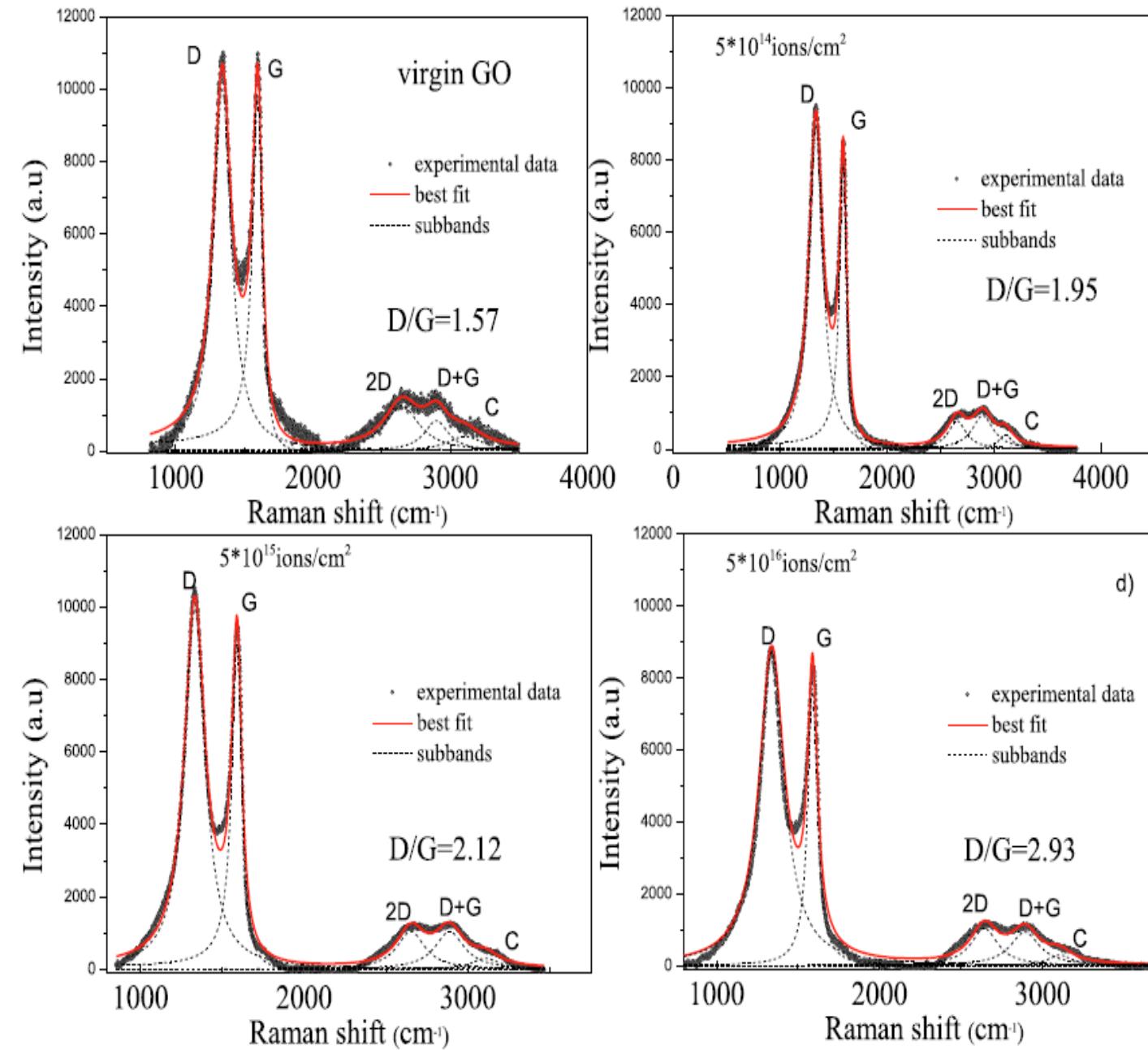
Sample	C 1s (at%)	O 1s (at%)	C/O ratio
Pristine GO foil	71.8	28.2	2.55
2.5 MeV H <sup>+</sup> $1.0 \times 10^{13} \text{ cm}^{-2}$	68.9	31.1	2.15
2.5 MeV H <sup>+</sup> $1.0 \times 10^{14} \text{ cm}^{-2}$	70.3	29.7	2.37
2.5 MeV H <sup>+</sup> $1.0 \times 10^{15} \text{ cm}^{-2}$	75.2	24.8	3.03
5.1 MeV He <sup>2+</sup> $1.0 \times 10^{13} \text{ cm}^{-2}$	70.7	29.3	2.41
5.1 MeV He <sup>2+</sup> $1.0 \times 10^{14} \text{ cm}^{-2}$	71.0	29.0	2.45
5.1 MeV He <sup>2+</sup> $1.0 \times 10^{15} \text{ cm}^{-2}$	78.5	21.5	3.65

## C/O α Ion dose and stopping power



L. Torrisi et Al., Vacuum 153 (2018) 122-131.  
 P. Malinski et Al., NIM B In press 2019.  
 M. Cutroneo et Al., Vacuum 165 (2019), 134-138.

# Raman Spectroscopy



2 MeV  $\text{He}^+$  ion beam irradiation

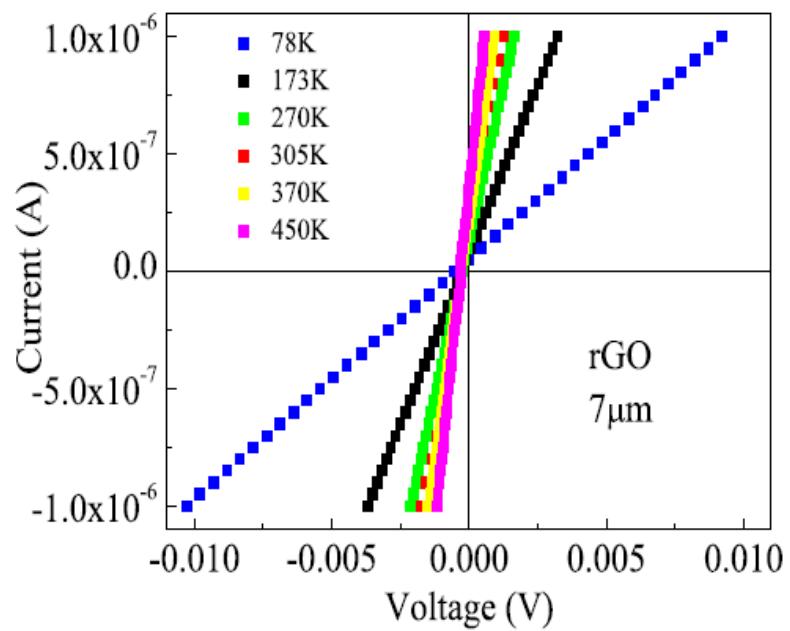
D/G  $\alpha$  Ion dose



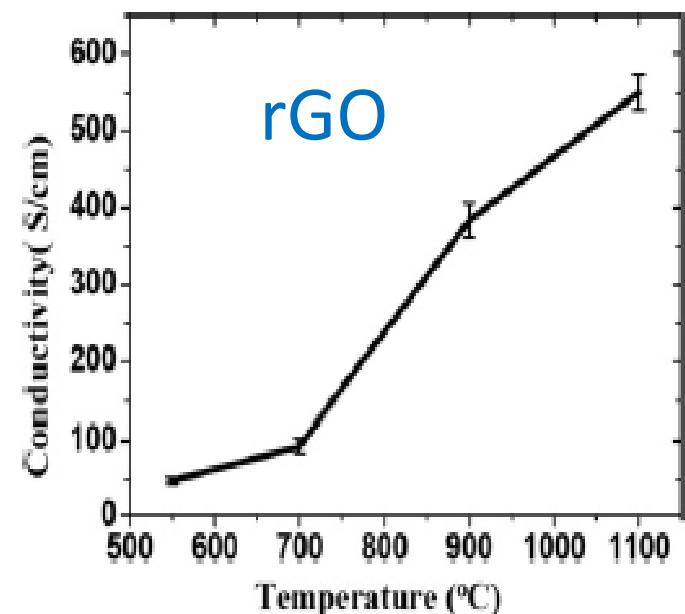
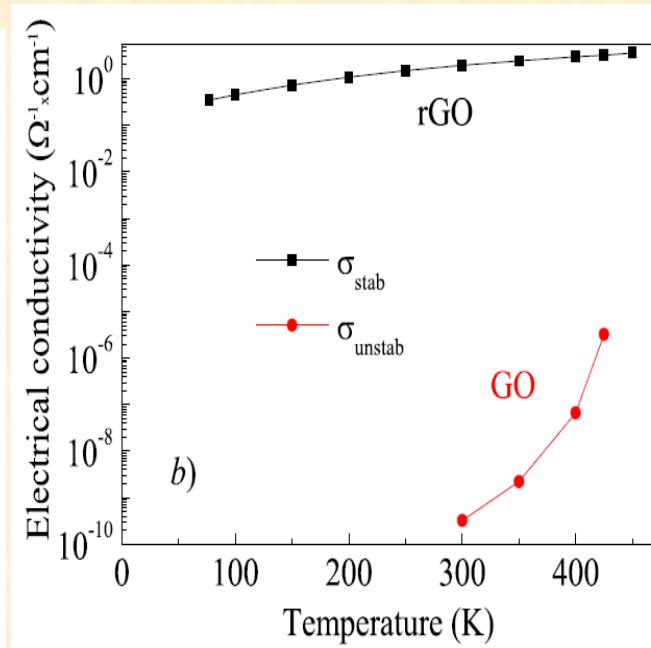
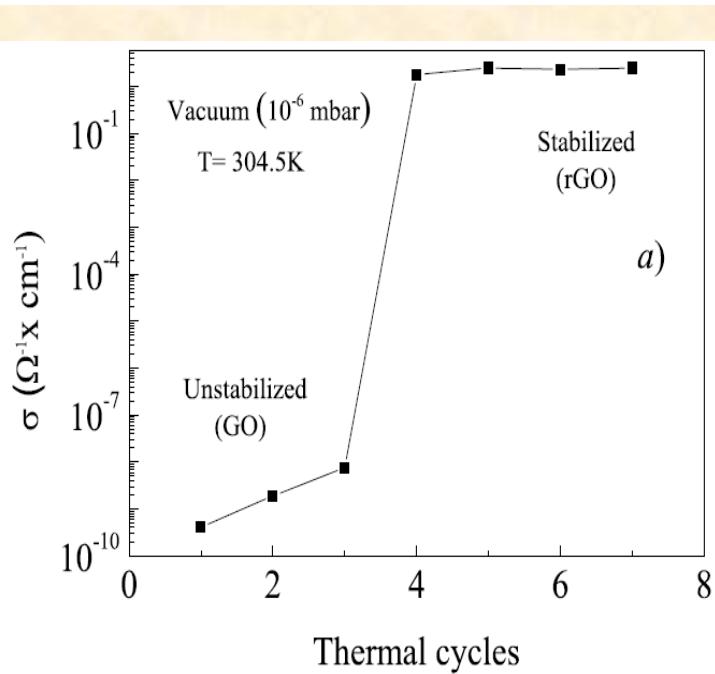
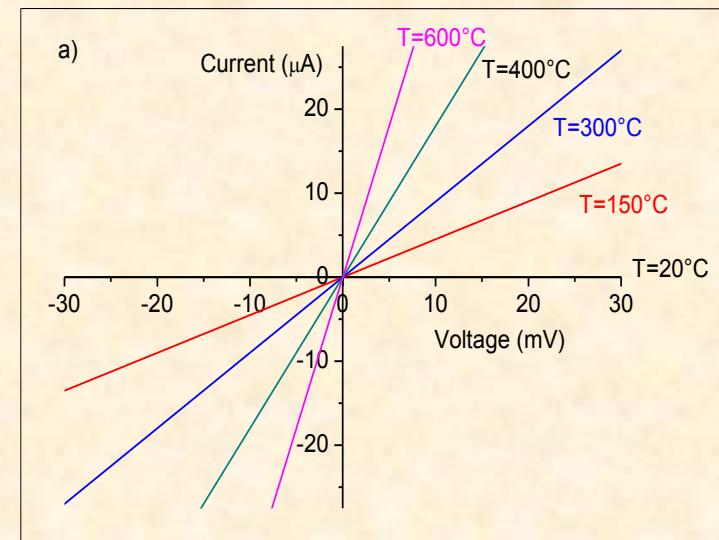
- Reduction of  $\text{sp}^2$  domain sizes;
- Increment of the number of  $\text{sp}^2$  domains.
- Increment of disorder;

L. Torrisi et Al.,  
*Vacuum* 160 (2019),  
1-11.

# Electrical Characterizations

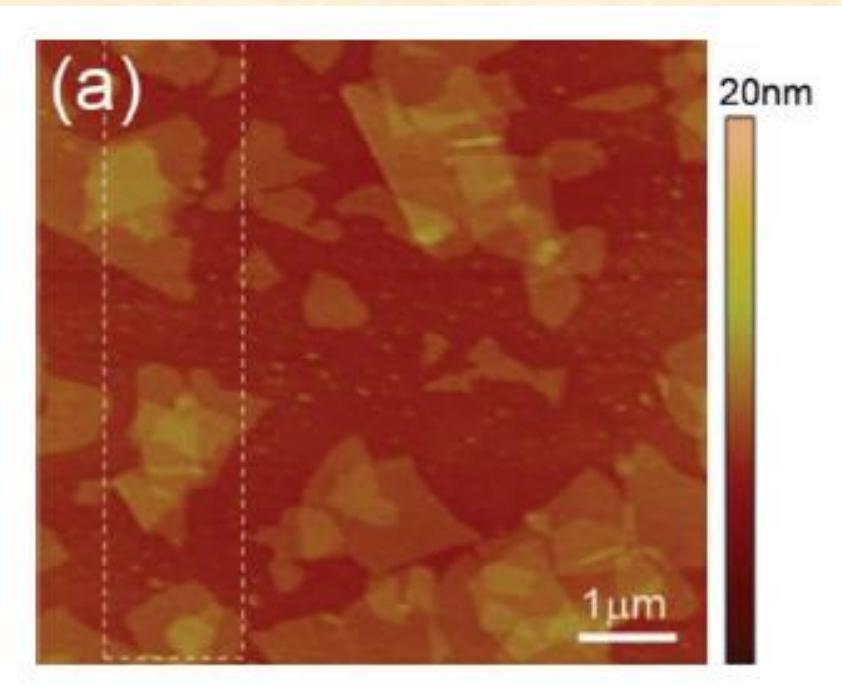


L. Silipigni et Al.,  
Vacuum 165, 2019,  
254-261.

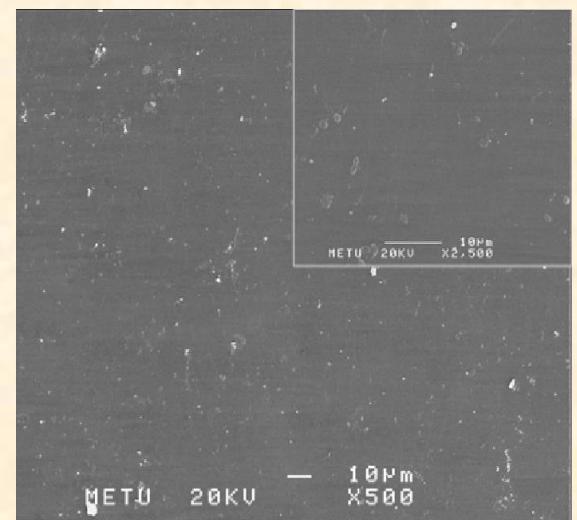


# Microscopy investigations

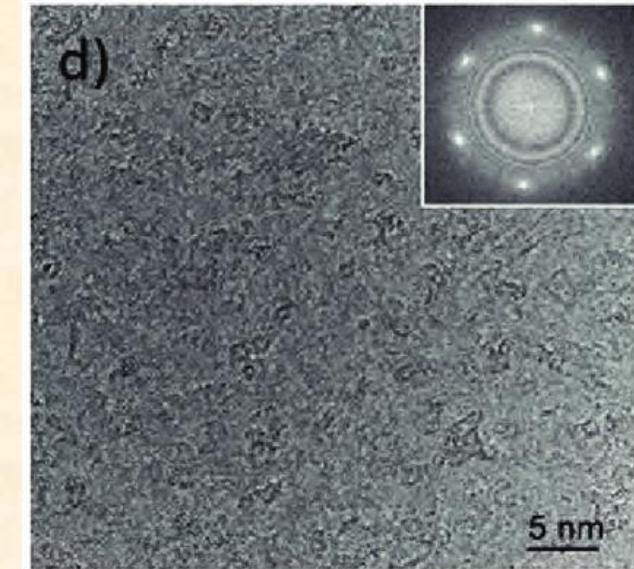
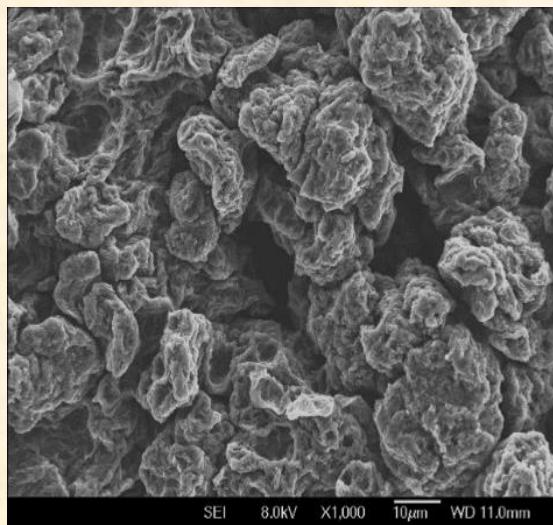
AFM analysis



SEM analysis

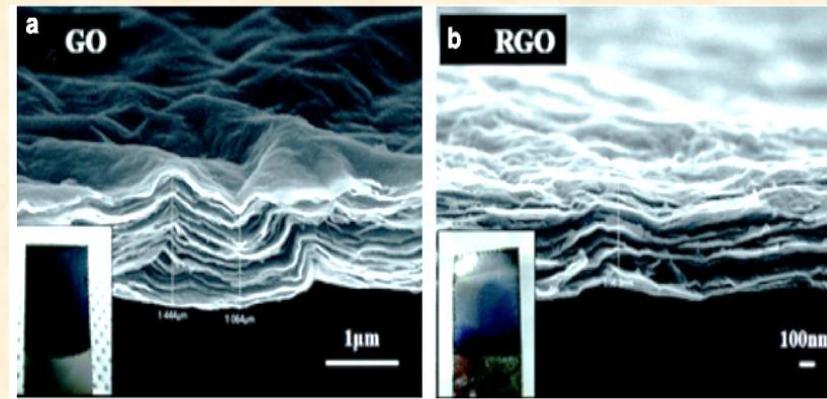


rGO



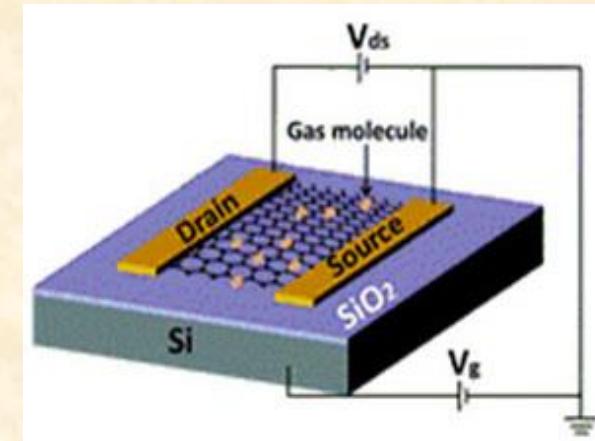
TEM analysis, rGO

Cross sections

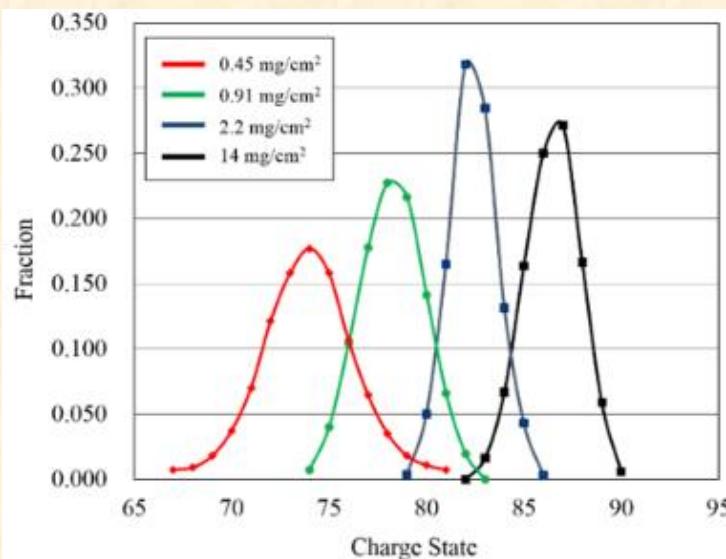


## Applications:

- Hydrogen and Deuterium storage material
- Thermal sensor
- Gas sensor
- Biomaterials
- Optical absorber
- Electronic devices (Batteries, resistances, capacitances, supercapacitors, schottky junctions, transistors, semiconductive strips,...)
- Filter membrane
- Ion Stripper**
- ...**



Gas sensor



Charge state distributions  
vs. foil thickness

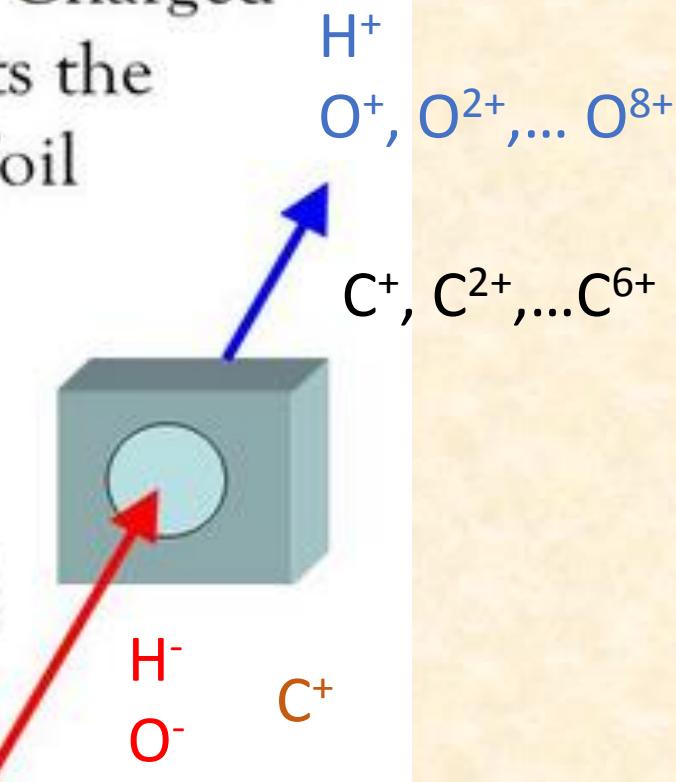
# The Stripper Foil

- A thin carbon foil is placed in the beam tube at the center of the terminal. As the negatively charged beam strikes the foil (at fairly high energy), electrons are stripped from the ions, leaving them positively charged.

Positively Charged Beam Exits the Stripper Foil

10-  
100  $\mu\text{g}/\text{cm}^2$

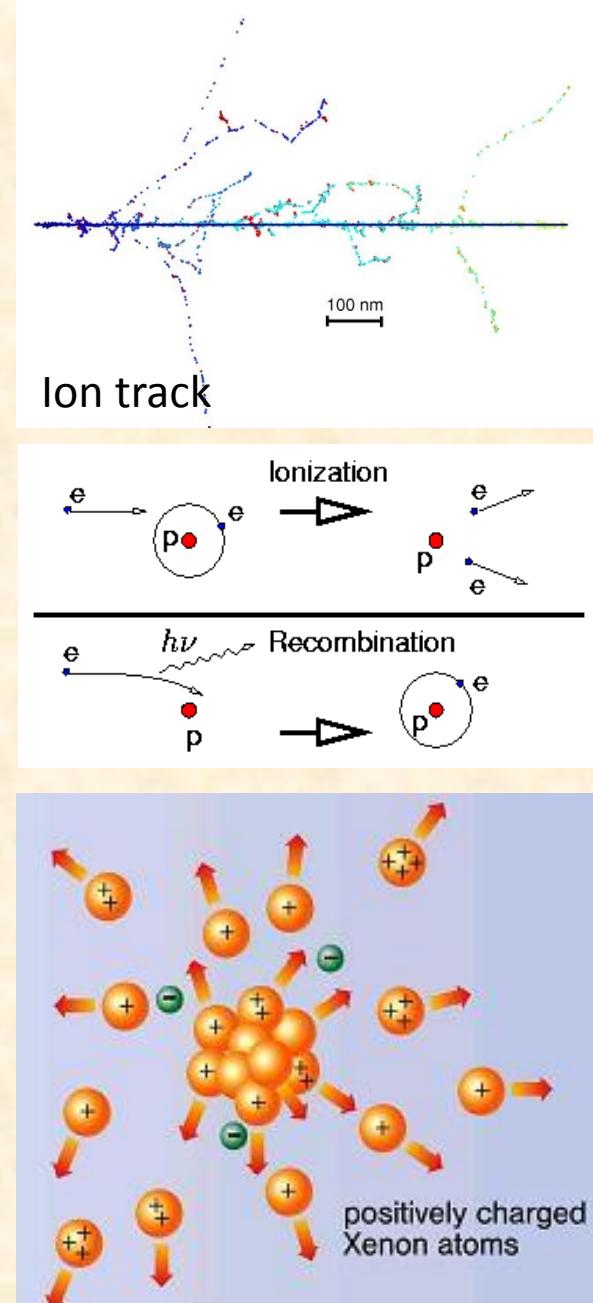
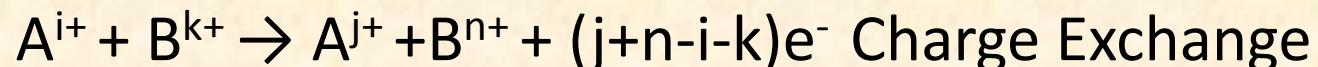
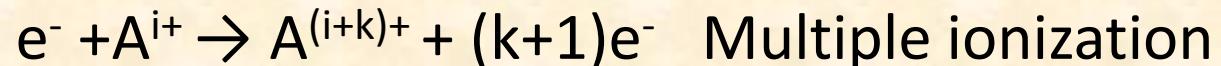
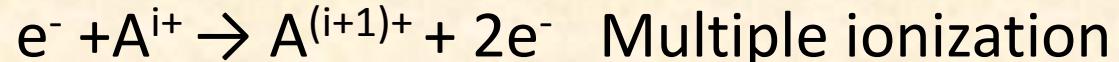
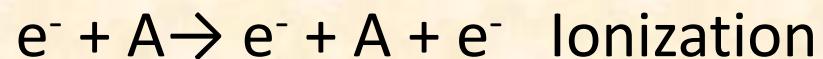
Carbon Stripper Foil



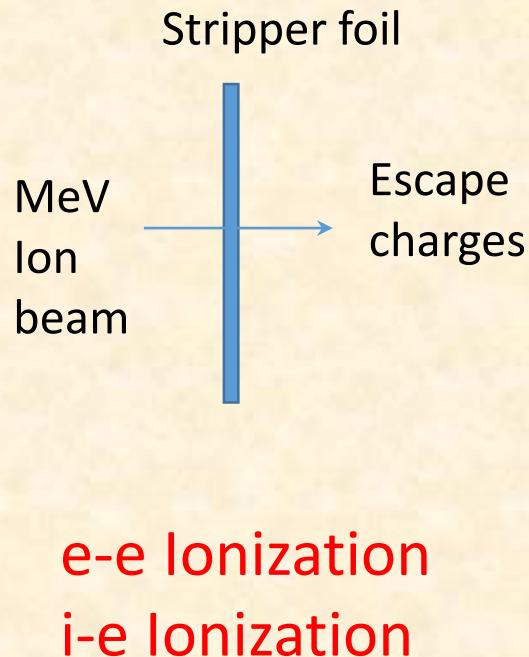
Negatively Charged Beam Enters the Stripper Foil

(10-100  $\mu\text{g}/\text{cm}^2 \approx 0.05\text{-}0.5 \mu\text{m}$ )

## Involved processes inside the stripper foil:

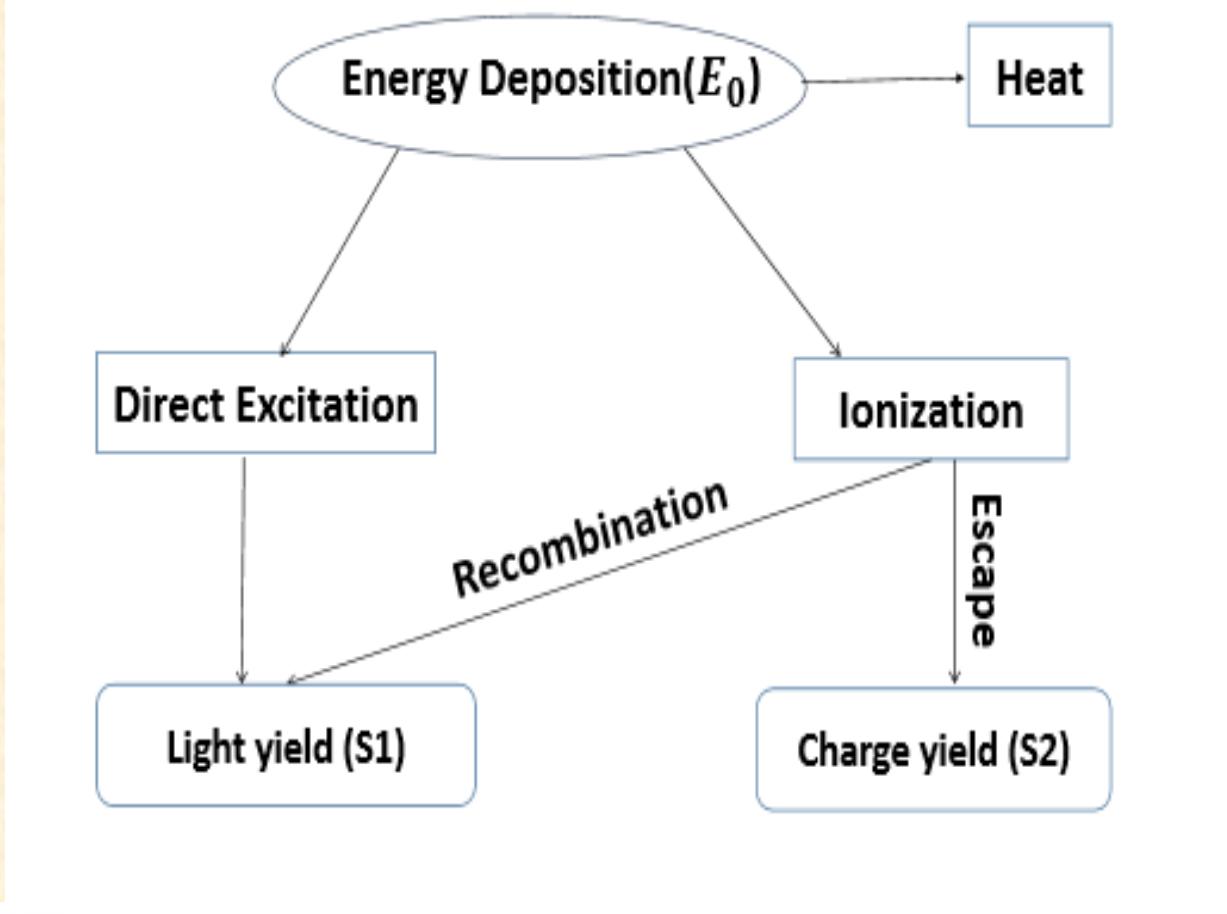


$\sigma$  cross-section ( $E, z, Z$ )

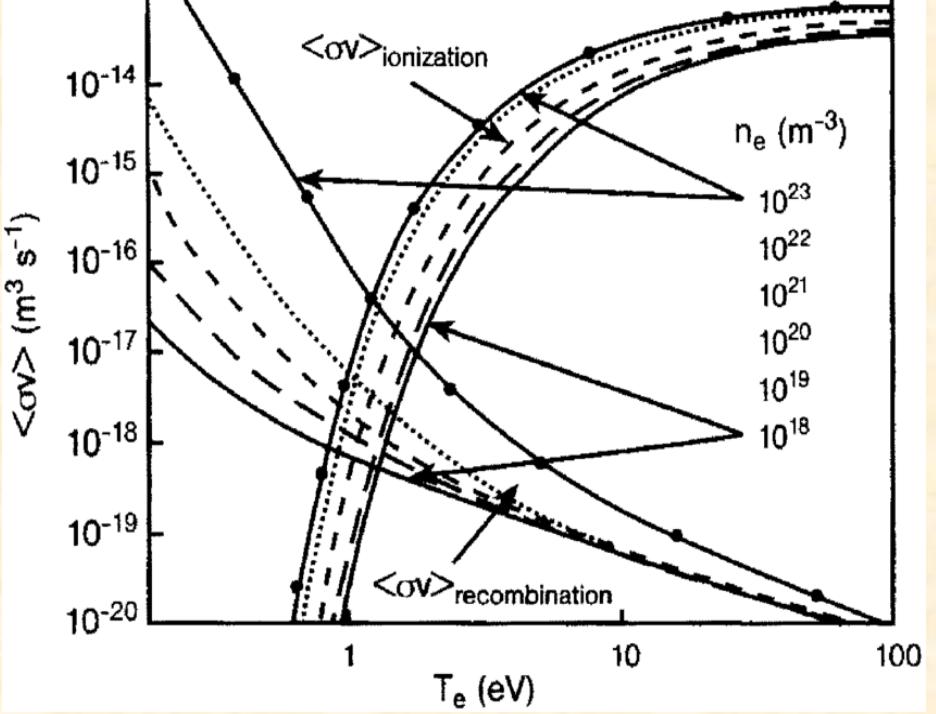


extraction foil

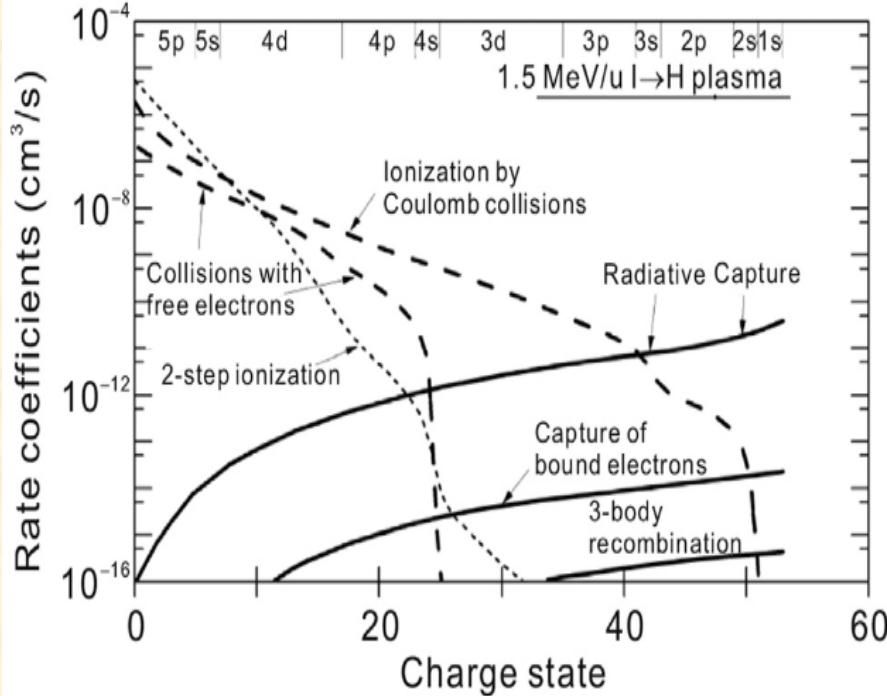
- thin foil, for example carbon, removes the electron(s) with high probability
- new charge state of ion brings it on a new trajectory → separation from circulating beam
- lifetime of foil is critical due to heating, rad.damage; conversion efficiencies, e.g. generation of neutrals, must be considered carefully



## i-e Recombination



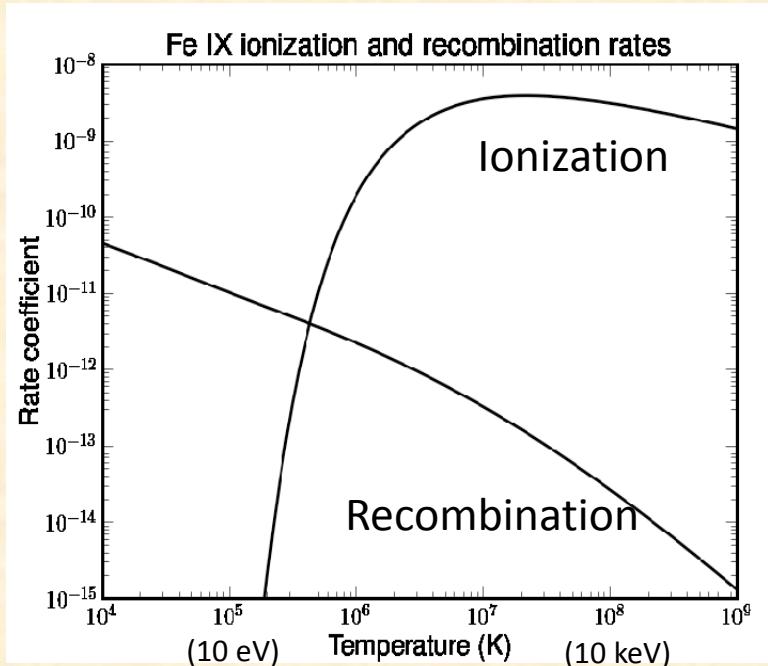
Theory



1)  $\sigma_{ionization} \propto E/q$

Equilibrium:  $\sigma_{ionization} = \sigma_{recombination}$  for each charge state ( $E, q, \Delta t$ , material parameters, ...)

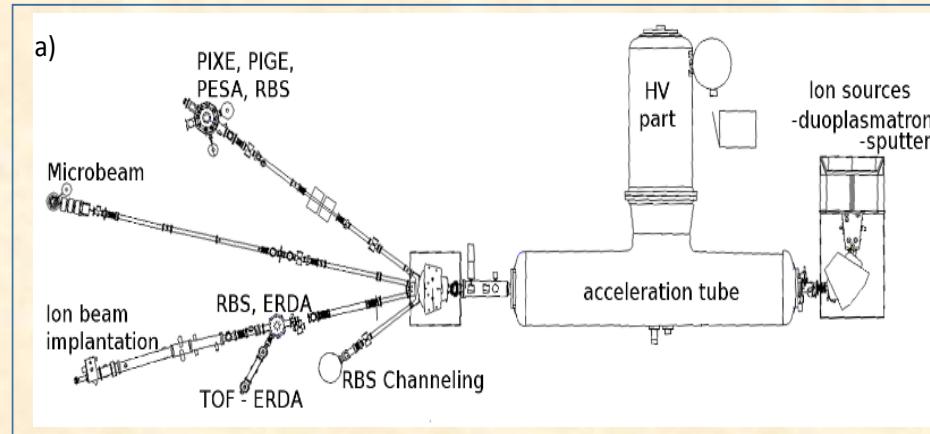
Ionization cross sections have a maximum value at the Bohr velocity



2)  $\sigma_{recombination} \propto q/E$

C. Deutsch  
Matter Radiat. Extremes 1, 277 (2016)

# Nuclear Physics Institute, Rez Academy of Science of Czech Republic, CANAM-TANDEMTRON Laboratory



## Investigated ions:

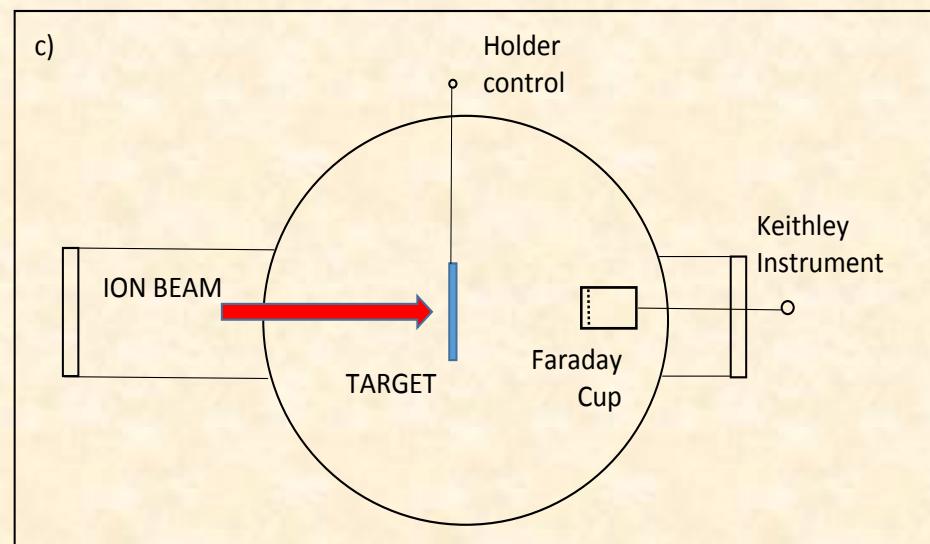
He, C, O ion beams  
1 - 24 MeV energy

1 - 100 nA currents

Spot size 1-25 mm<sup>2</sup>

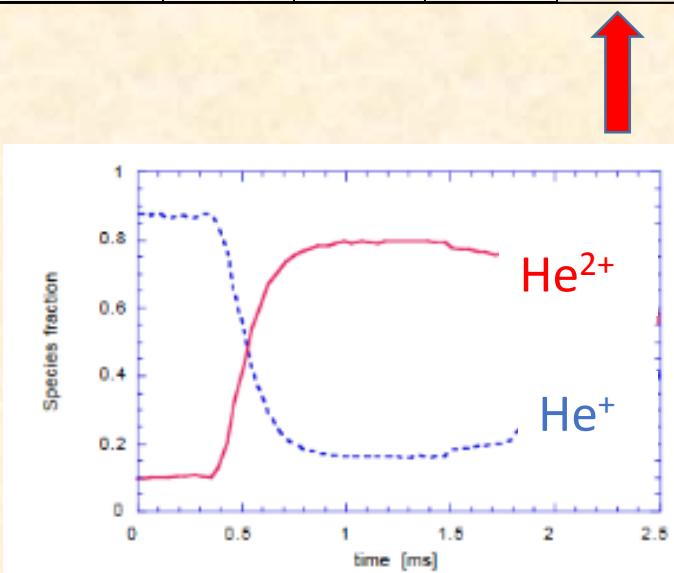
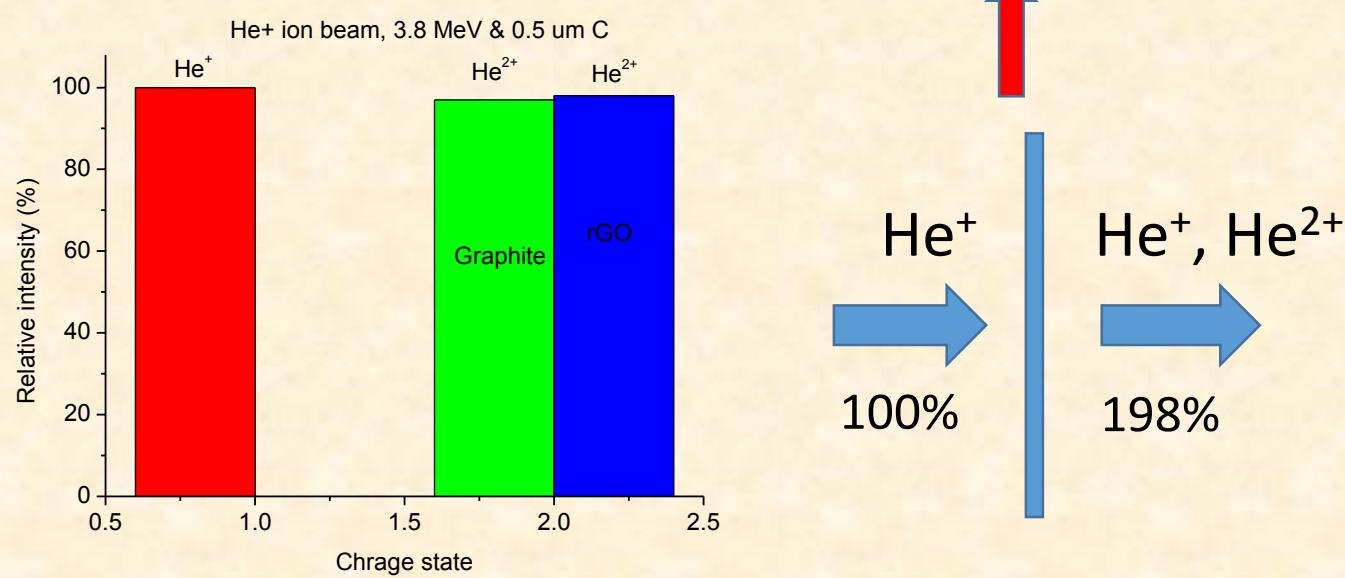
## Transmitted current measurements:

$$T = I_t / I_0$$



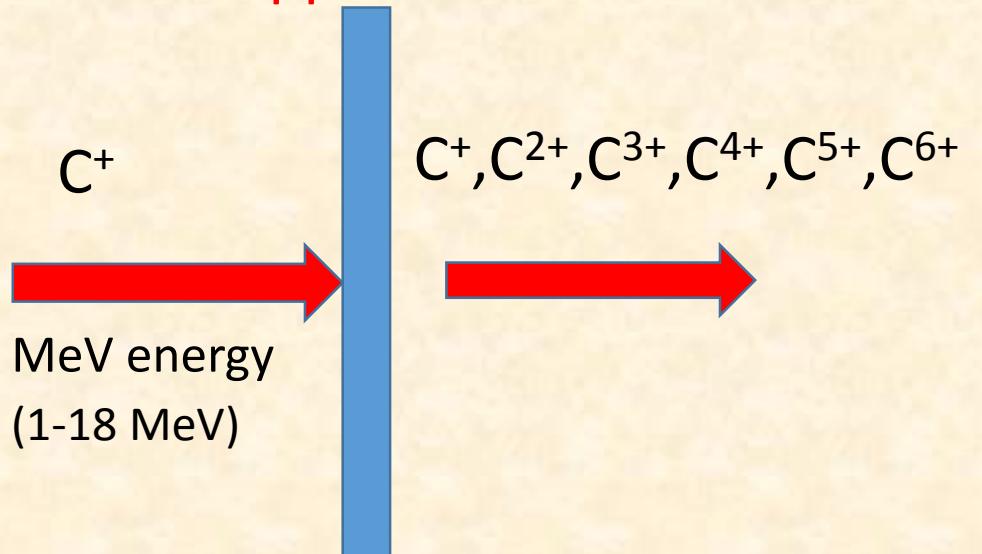
# $\text{He}^+$ beam

	Graphite ( $\rho = 2.25 \text{ g/cm}^3$ ), 0.5 $\mu\text{m}$					RGO ( $\rho = 1.50 \text{ g/cm}^3$ ), 0.5 $\mu\text{m}$ , 1.0 $\mu\text{m}$ , 2.0 $\mu\text{m}$					
Energy (MeV)	Range in Graphite ( $\mu\text{m}$ )	Lateral Straggling nm/0.5 $\mu\text{m}$	$I_0$ (nA)	$I_T$ (nA)	$T$	Range in RGO ( $\mu\text{m}$ )	Lateral Straggling nm/0.5 $\mu\text{m}$	$\Delta x$ ( $\mu\text{m}$ )	$I_0$ (nA)	$I_T$ (nA)	$T$
					$I_T/I_0$						$I_T/I_0$
1.0	2.70	25	3.5	6.9	1.97	4.05	25	1.0	3.5	6.95	1.98
2.0	5.48	16	3.5	6.9	1.97	8.22	16	1.0	3.5	6.9	1.97
2.9	8.63	13	5.0	9.8	1.96	12.95	13	0.5	5.1	10	1.97
2.9	"	"	5.1	10	1.96	"	"	1.0	5.1	10	1.96
2.9	"	"	5.3	10	1.89	"	"	2.0	5.3	10.1	1.91
3.8	12.41	11	7.4	14.4	1.95	18.62	11	1.0	7.4	14.3	1.93

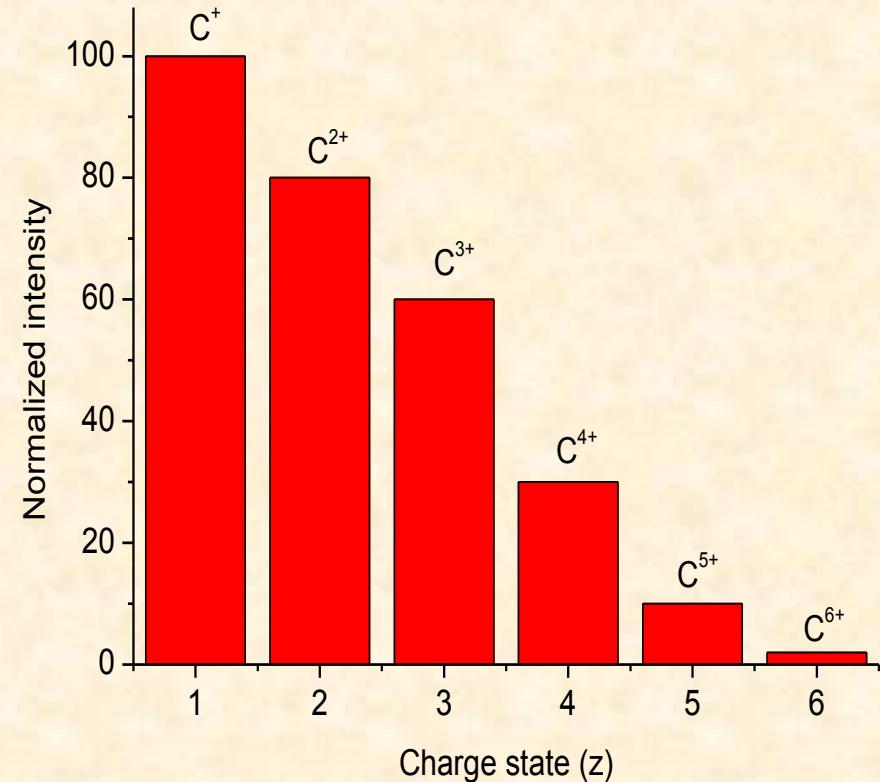


rGO Stripper foil

## Equilibrium between ionization and recombination effects



Sub-micrometric foil thicknesses  
(10-100  $\mu\text{g}/\text{cm}^2 \approx 0.05\text{-}0.5 \mu\text{m}$ )

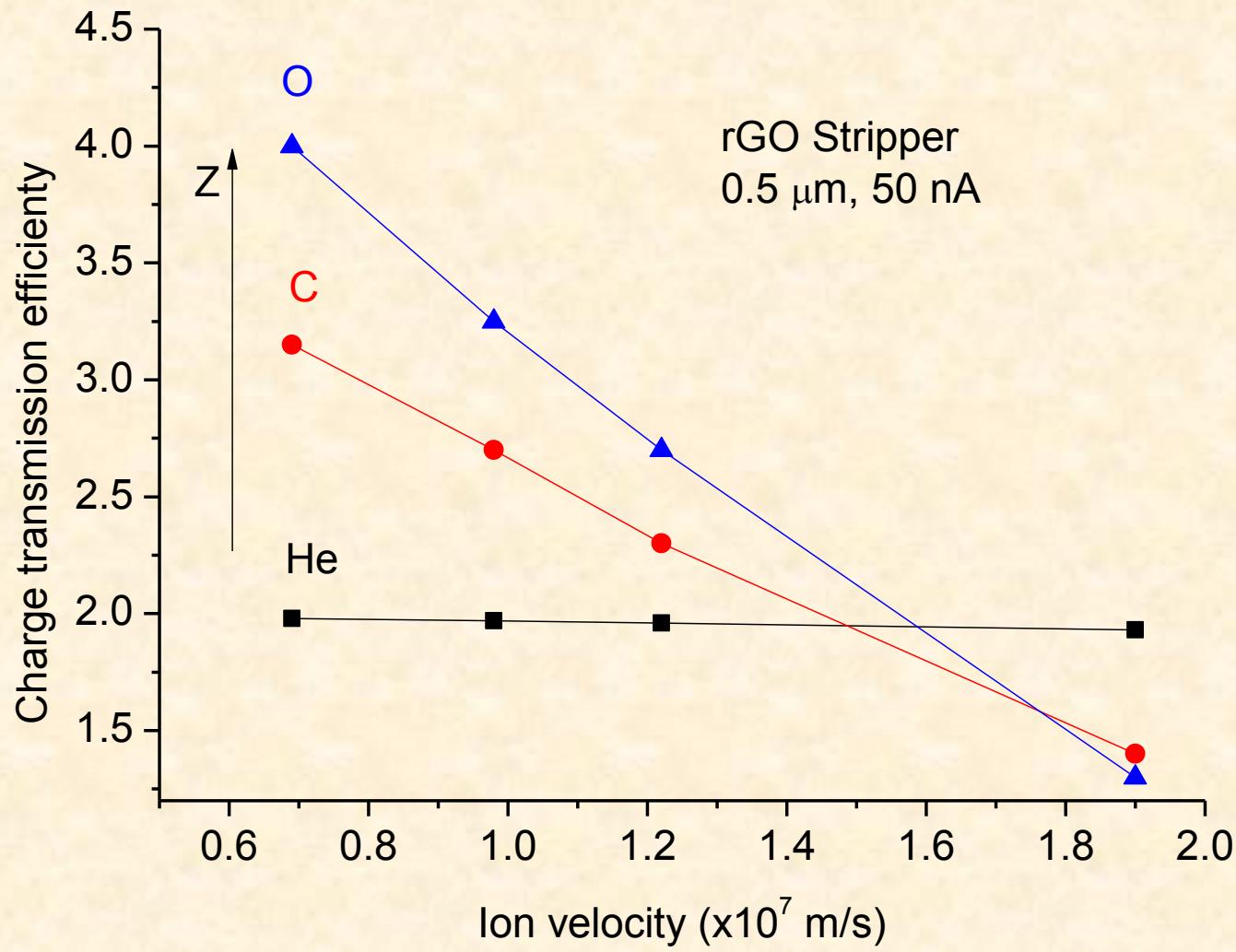


### C<sup>5+</sup> beam

#### Graphite ( $\rho = 2.25 \text{ g/cm}^3$ ), 0.44 $\mu\text{m}$

#### rGO ( $\rho = 1.50 \text{ g/cm}^3$ ), 0.5 $\mu\text{m}$ , 1.0 $\mu\text{m}$

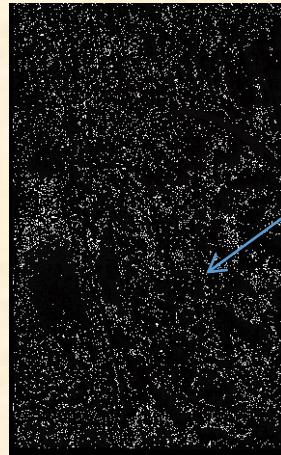
Energy (MeV)	Range in Graphite ( $\mu\text{m}$ )	Lateral Straggling (nm)	$I_0$ (nA)	$I_T$ (nA)	$T$ $I_T/I_0$	Range in RGO ( $\mu\text{m}$ )	Lateral Straggling (nm)	$\Delta x$ ( $\mu\text{m}$ )	$I_0$ (nA)	$I_T$ (nA)	$T$ $I_T/I_0$
16	11.55	9	2.15	2.18	1.01	17.33	9	0.5	2.09	2.10	1.0
16	"	"				"	"	1.0	2.08	2.10	1.01
<b>C<sup>4+</sup> beam</b>											
13.3	9.40	7	6.05	7.3	1.21	14.10	10	0.5	6.2	7.53	1.21
13.3	"	"				"	"	1.0	6.2	7.56	1.22
<b>C<sup>3+</sup> beam</b>											
10	6.98	8.5	7.0	11	1.57	10.48	12	0.5	7.1	11.2	1.58
10	"	"				"	"	1.0	7.2	11.4	1.58
<b>C<sup>2+</sup> beam</b>											
8	5.63	10	7.38	15.62	2.11	8.44	14	0.5	7.7	16.7	2.16
8	"	"				"	"	1.0	7.4	15.4	2.08
<b>C<sup>+</sup> beam</b>											
3.2	2.65	19.5	10.4	34.18	3.27	3.98	29	0.5	10.2	32.1	3.15
3.2	"	"	5			"	"	1.0	9.39	28.2	3.0



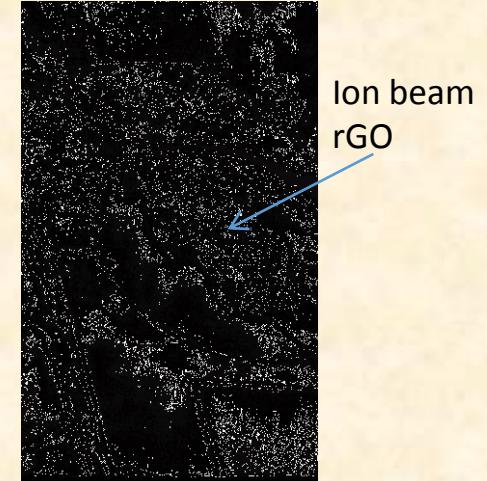
# Preparation



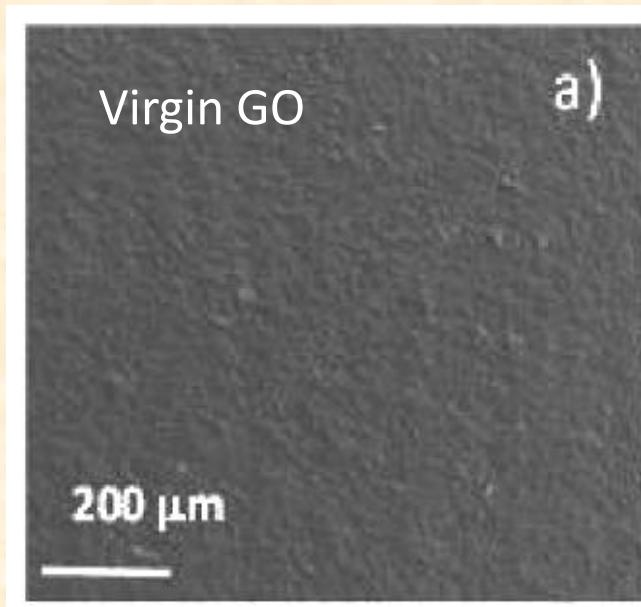
# Graphite stripper



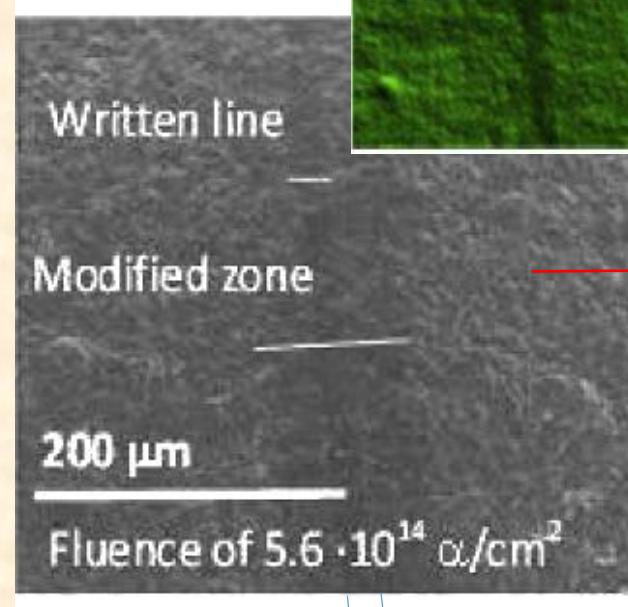
# rGO stripper



ion pattern

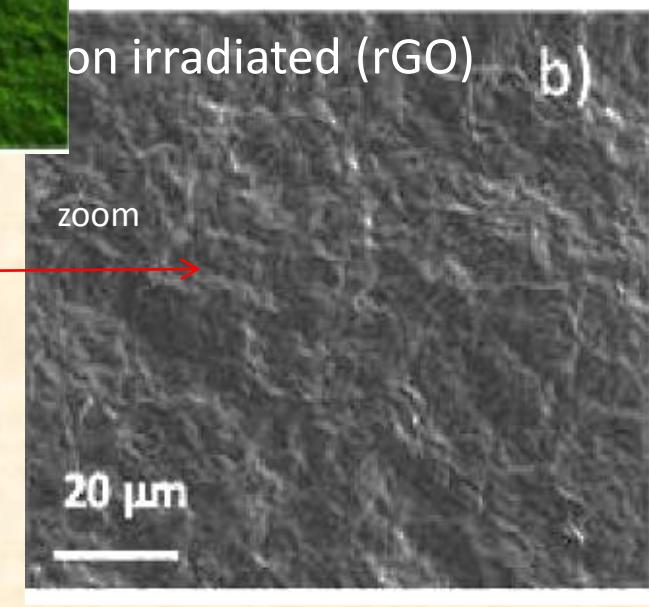


a)

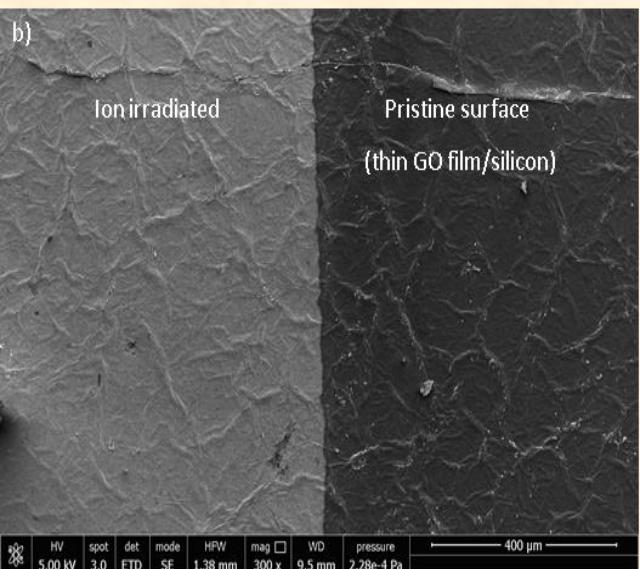
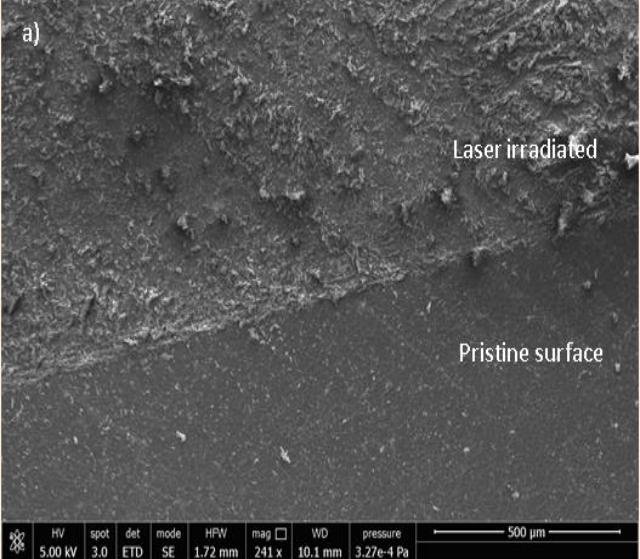


Fluence of  $5.6 \cdot 10^{14} \alpha/\text{cm}^2$

Ion beam line



b)



M. Cutroneo et Al.,  
*EPJ Web of Conferences* 167,  
02004 (2018)

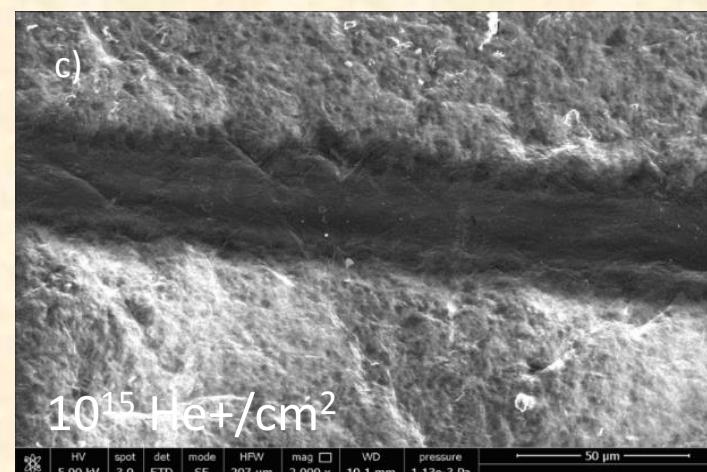
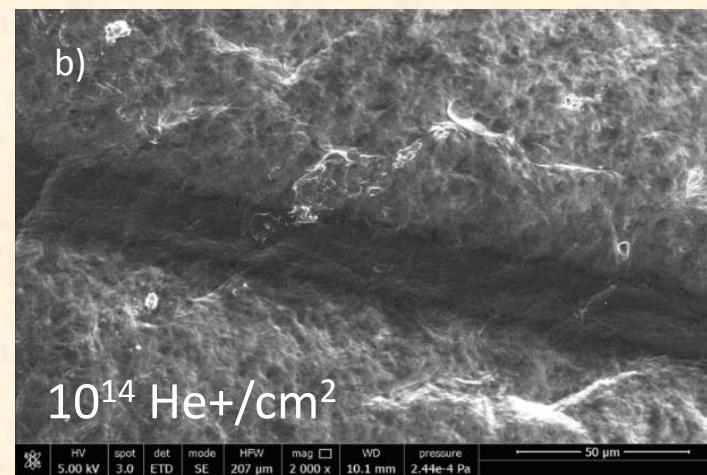
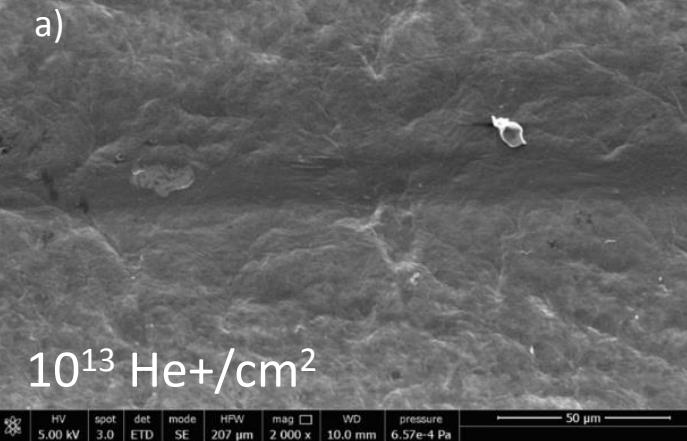
V. Romano et Al.,  
*EPJ Web of Conferences* 167,  
04011 (2018)

L. Silipigni et Al.,  
*EPJ Web of Conferences* 167,  
05011 (2018)

L. Torrisi et Al.,  
*Rad. Eff. and Def. in solids*,  
173:1-2, 73-84 (2018)

M. Cutroneo et Al.,  
*Vacuum* 165 (2019) 134–138.

M. Cutroneo et Al.,  
*Nucl. Instr. and Methods B*,  
in press 2019.



Ion beam reduction with groove production (thinning),  
increasing density and approaching the sp<sup>2</sup> plains

## Main Results

1. Obtained results demonstrated that the stripping effect is similar for Graphite and rGO foils with the same thickness ( $\mu\text{g}/\text{cm}^2$ ).
2. Lifetime for rGO is higher than graphite thanks to the better mechanical and thermal properties of rGO

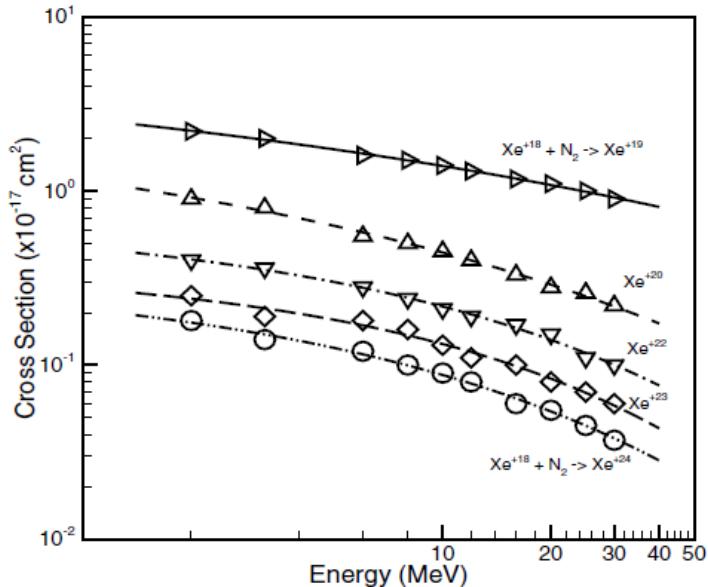


For a good quality of carbon foil is necessary to extract ion beams stable for a long time, thus the **lifetime** is an important parameter of such films.

# Preliminar Observations

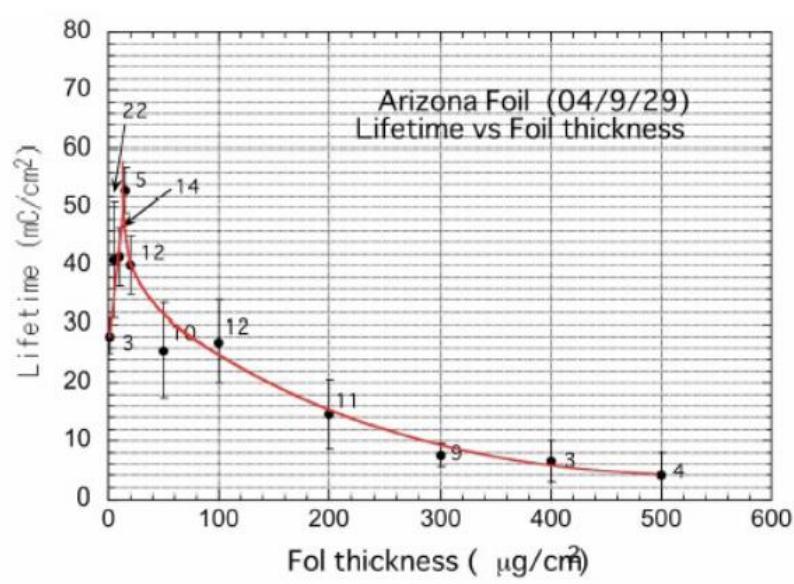
- GO foil (0.4 mm) under helium ion bombardment at 100 nA exceeded  $\sim 5 \times 10^{17}$  He/cm<sup>2</sup> dose without disruption.
- Graphite foil (0.4 mm) at 100 nA was broken at  $\sim 5 \times 10^{16}$  He/cm<sup>2</sup>.
- No micro cracks are observed in GO and rGO with respect to Graphite.
- Graphite foils show micro cracks by thermal gradient effects and mechanical stresses, not observed in rGO foils.
- Important aspects concern the thermal dissipation of the stripper and of its holder.
- The multiple scattering from the foil increases the beam emittance and thus decreases transmission. The foil thickens under bombardment with heavy beams, resulting in a time-varying reduction in beam intensity and an increase in beam loading. **The foil lifetimes decrease as the beam mass and intensity increase.**

# Literature data

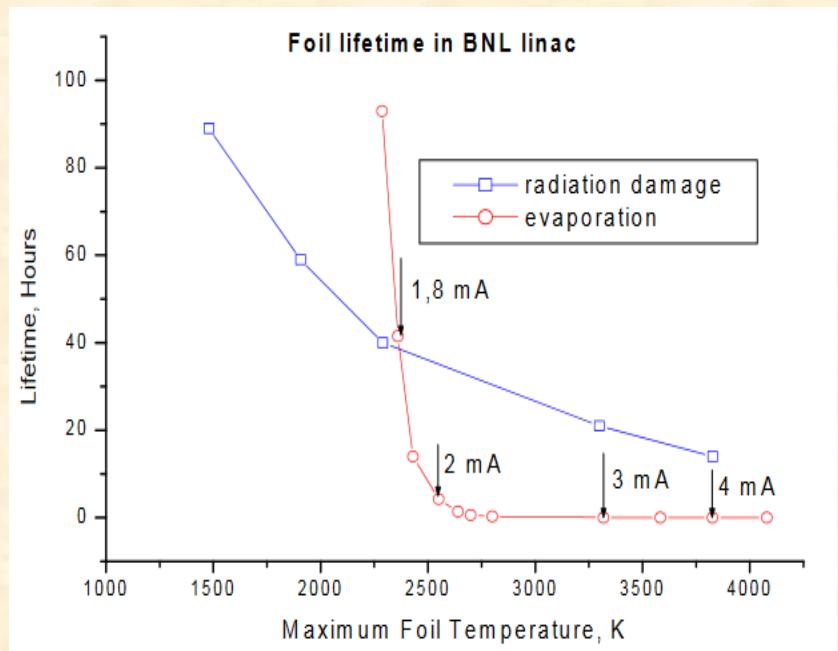
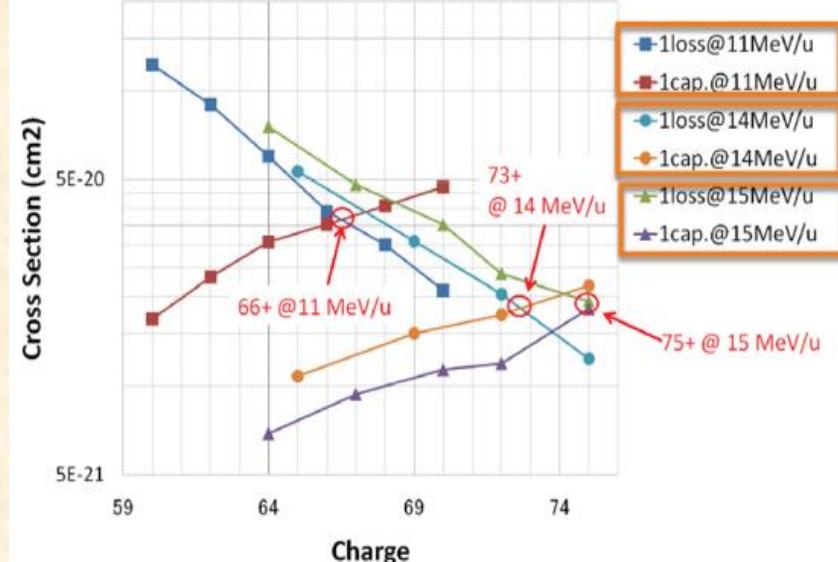


Ionization and recombination cross-sections vs charge

GH Miley et Al.,  
DOI:  
[10.1109/FUSION.2005.005252869](https://doi.org/10.1109/FUSION.2005.005252869) ·  
Source: IEEE Xplore, 2005

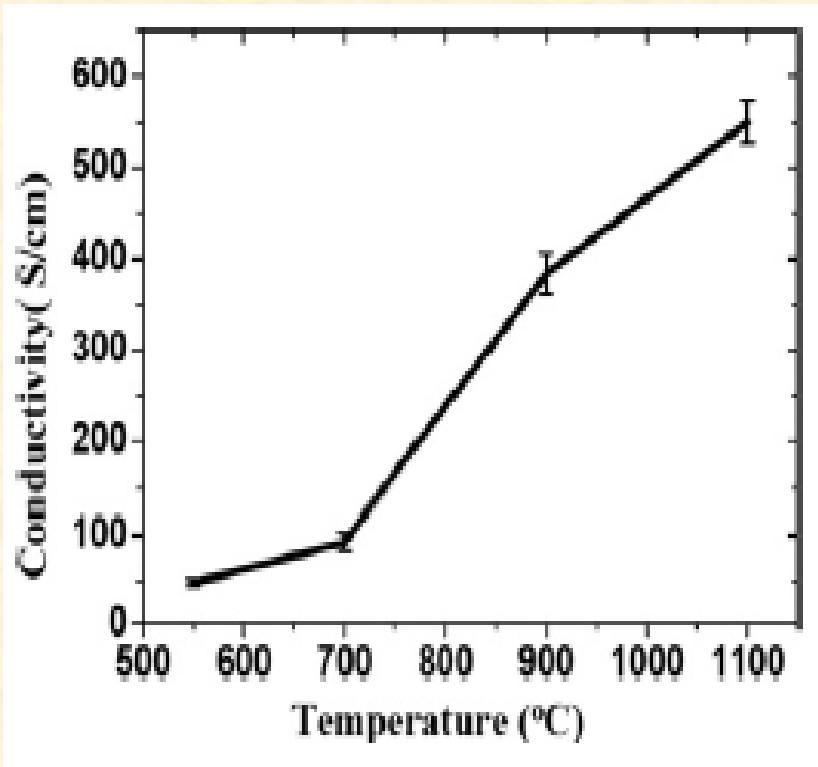


Lifetime versus foil thickness

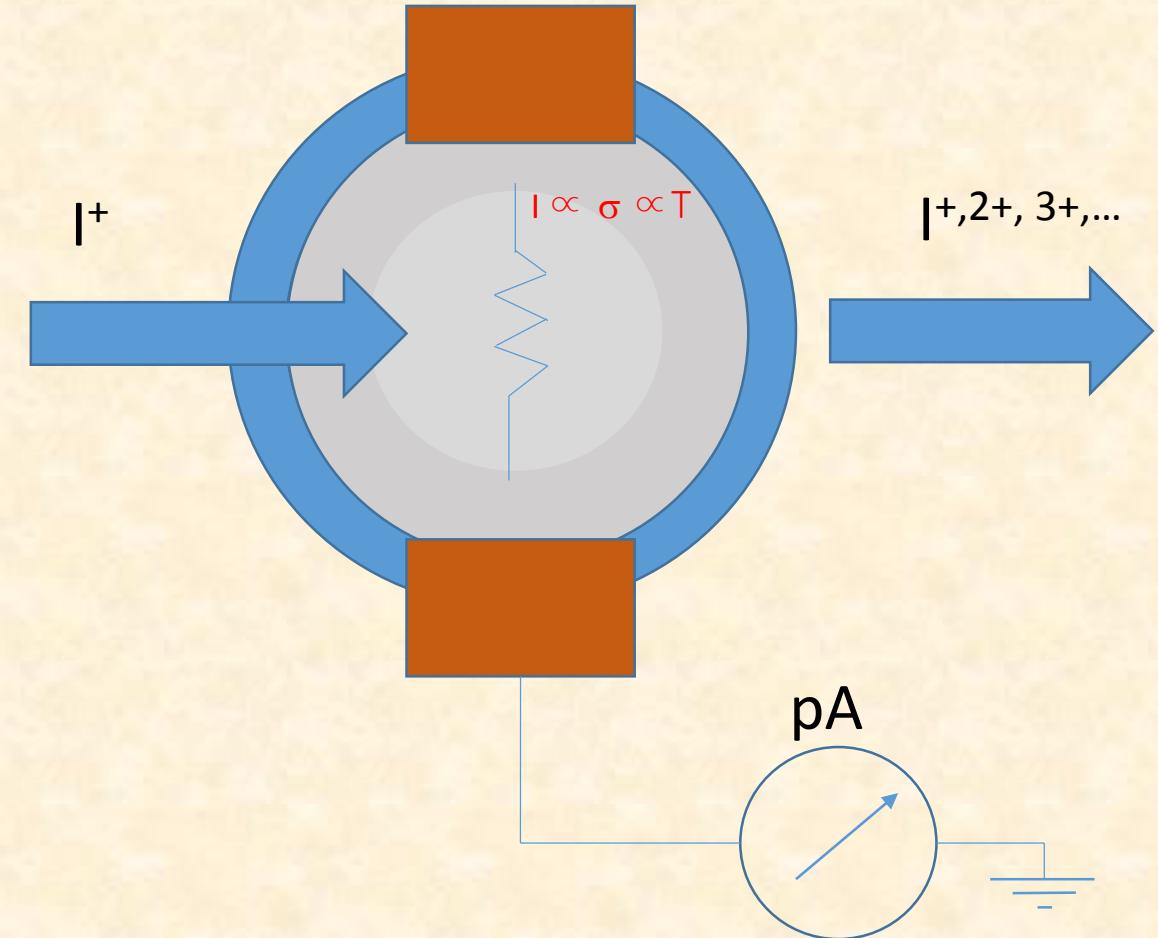


Lifetime versus foil temperature

## Future developments: rGO stripper foil sensitive to high temperature



(rGO temperature sensor)

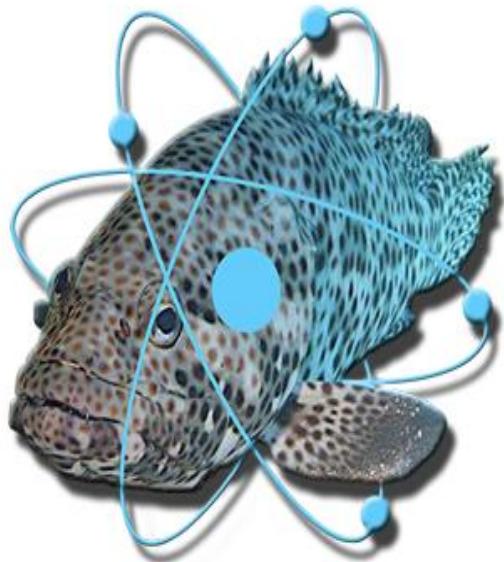


\* Feedback signal to stop the ion beam at high stripper temperature

## Conclusions

- GO foils have higher mechanical resistance than graphite
- rGO foils have high electrical and thermal conductivity, low density and high mechanical resistance
- GO foils become rGO under ion beam irradiation starting from about  $10^{13}$  ions/cm<sup>2</sup> fluence
- GO foils with sub-micrometric thickness can be used as ion stripper with high efficiency, similarly to Graphite foils
- The stripper lifetime of rGO foils is higher with respect to graphite foils
- Further investigation must be performed using high energy ions ( $\sim 100$  MeV), heavy ions ( $Z>8$ ) and high ion current ( $I>100$  nA) to evaluate the rGO stripper lifetime response with respect to graphite.

# Thank You for the Attention

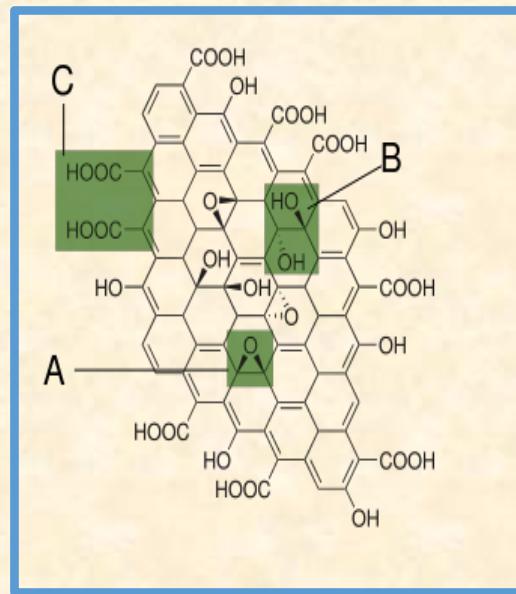
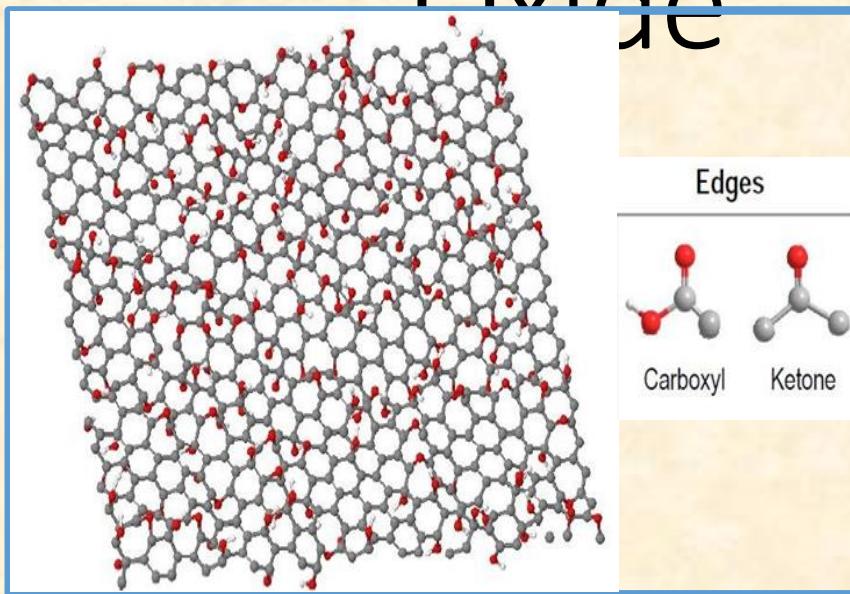


# CHERNE 2019

CHERNE 2019 -15th Workshop on European Collaboration in Higher Education on Radiological and Nuclear Engineering and Radiation Protection

2-5 June 2019  
Portopalo di Capo Passero

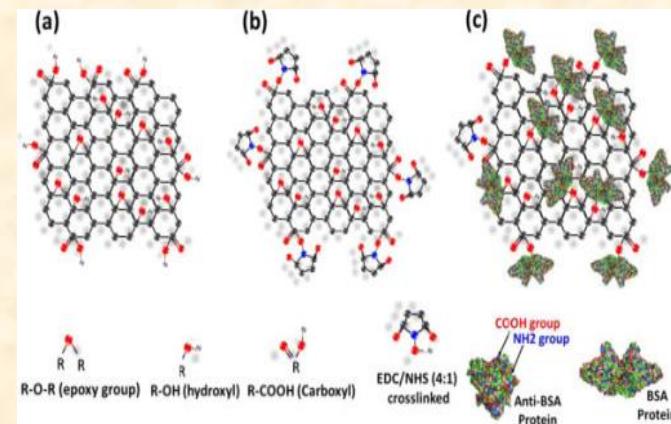
# Graphene Oxide



Functional groups:

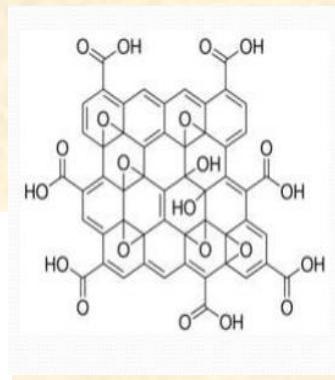
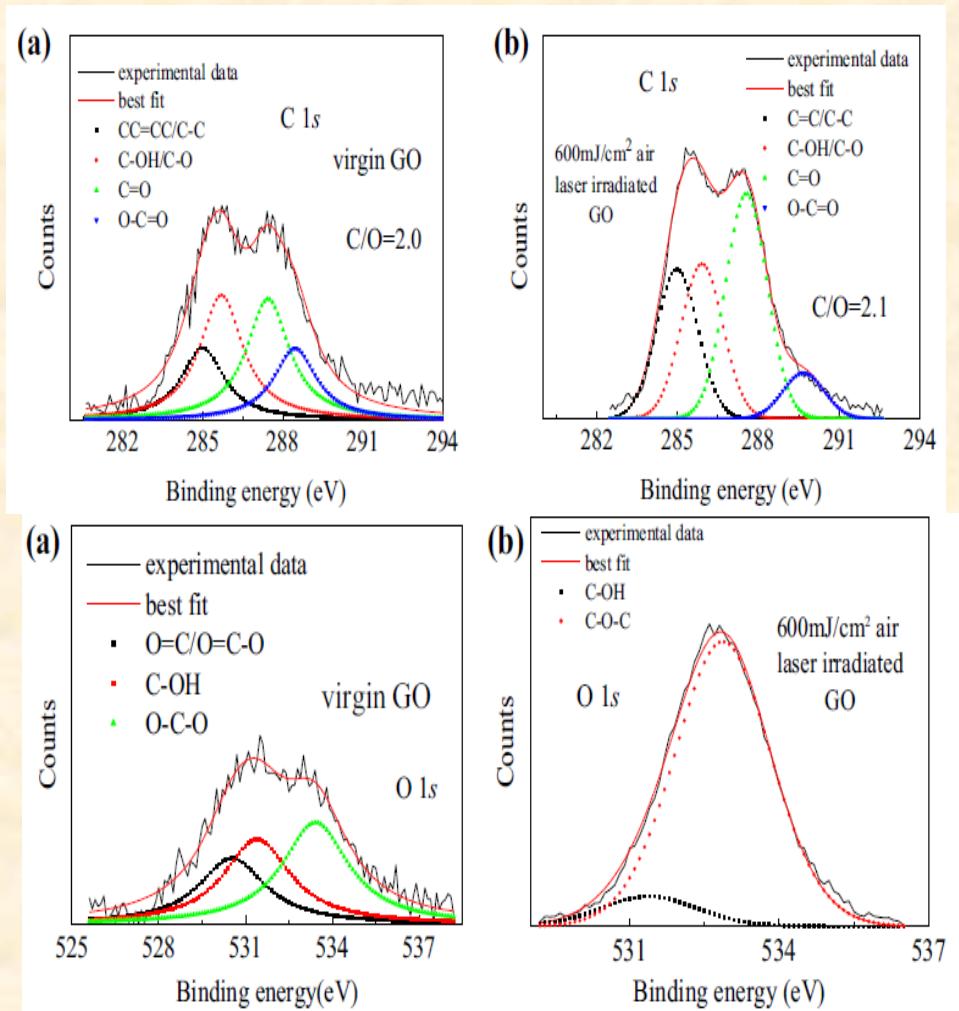


- hydroxyl (C-OH)
- epoxy (C-O-C)
- carbonyl (C=O)
- carboxyl (O-C=O)

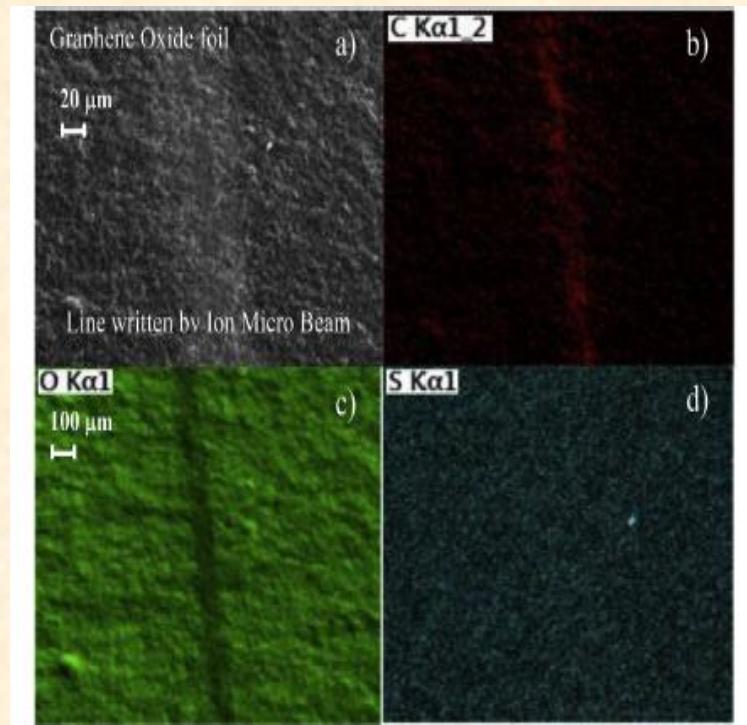
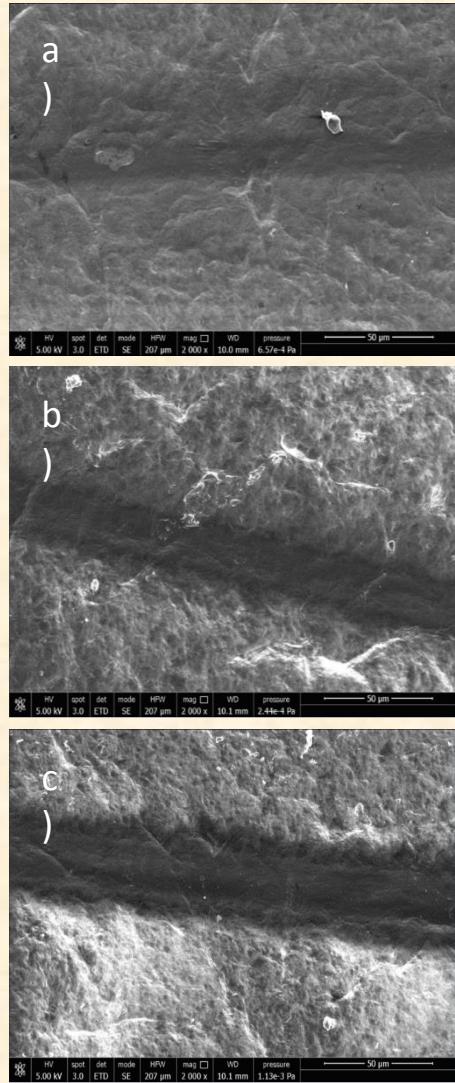


# XPS Analysis

L. Torrisi  
et Al.,  
*Vacuum*  
153  
(2018)  
122-131.



# Ion beam reduction and Patternig in insulator GO



The charge state distribution for  $(^{16}\text{O})^{-1}$  ions with 3.0 MV at the HV Terminal was:

$$\text{O}^+ = 0.5\%$$

$$\text{O}^{2+} = 0.8\%$$

$$\text{O}^{3+} = 1\%$$

$$\text{O}^{4+} = 10\%$$

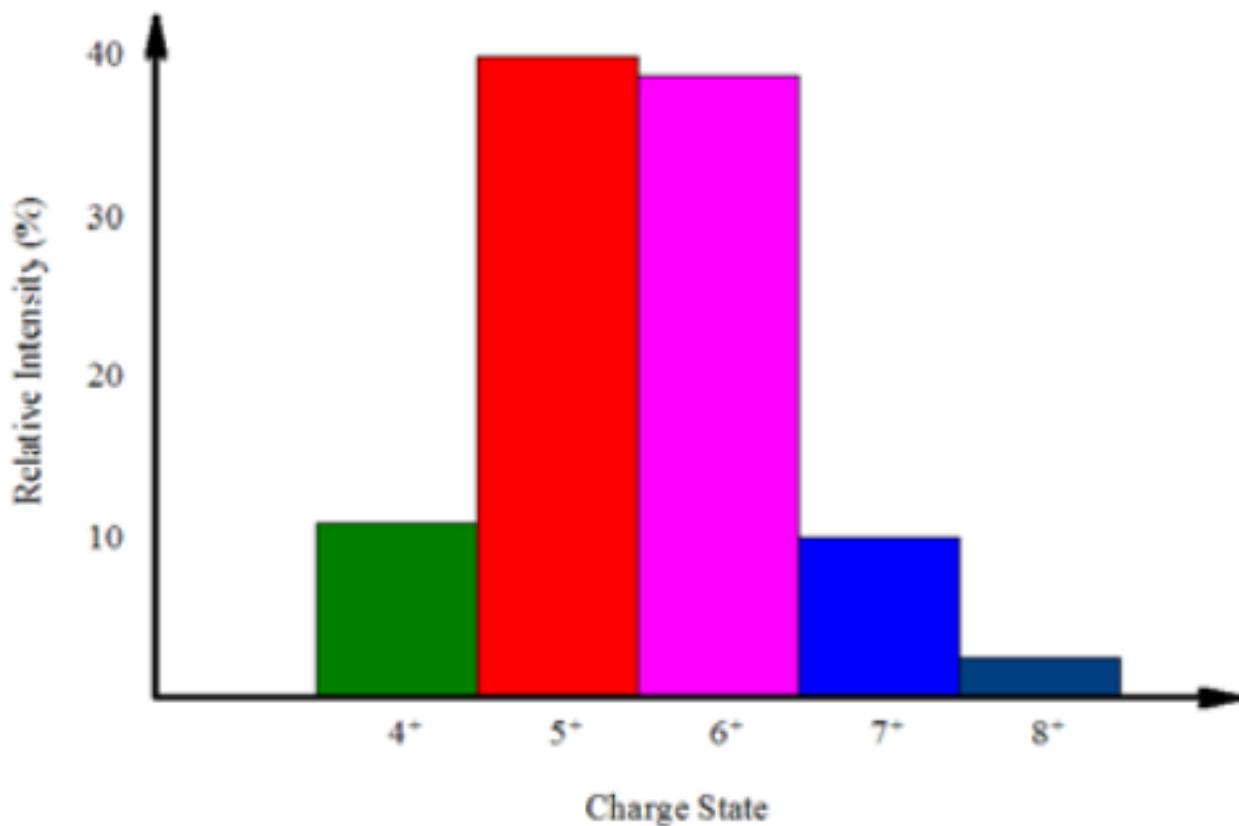
$$\text{O}^{5+} = 41\%$$

$$\text{O}^{6+} = 36\%$$

$$\text{O}^{7+} = 10\%$$

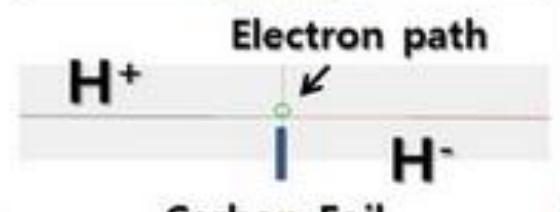
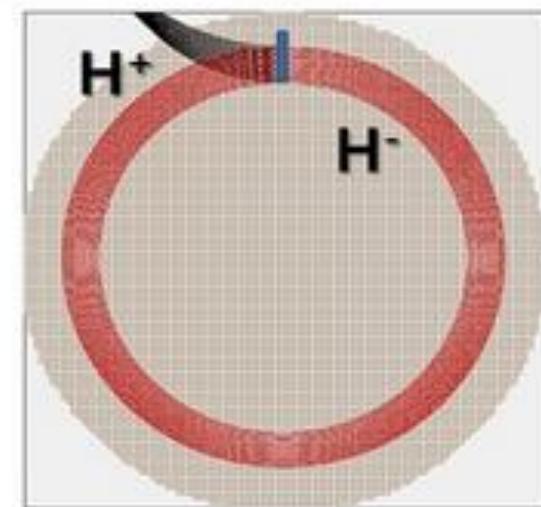
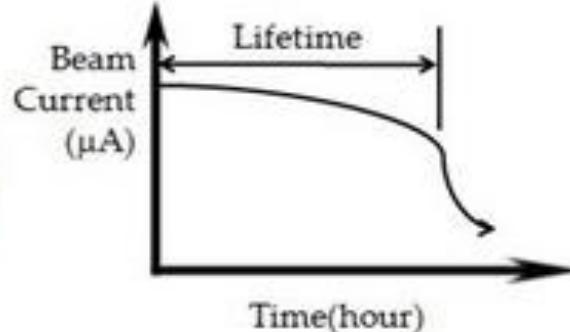
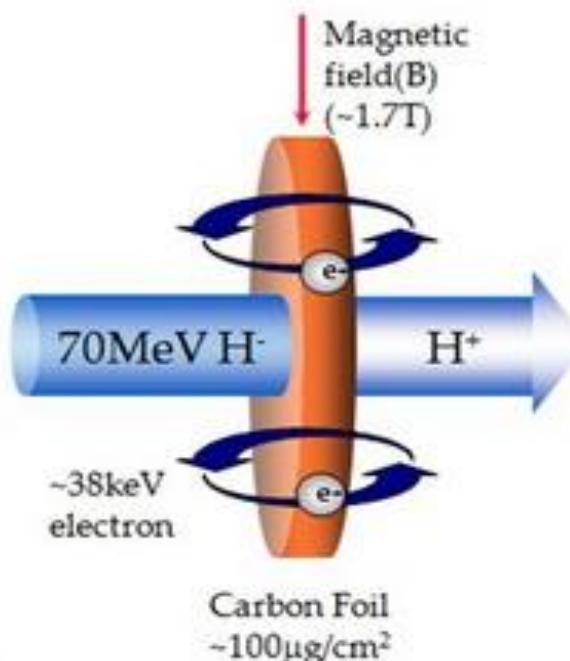
$$\text{O}^{8+} = 1\%$$

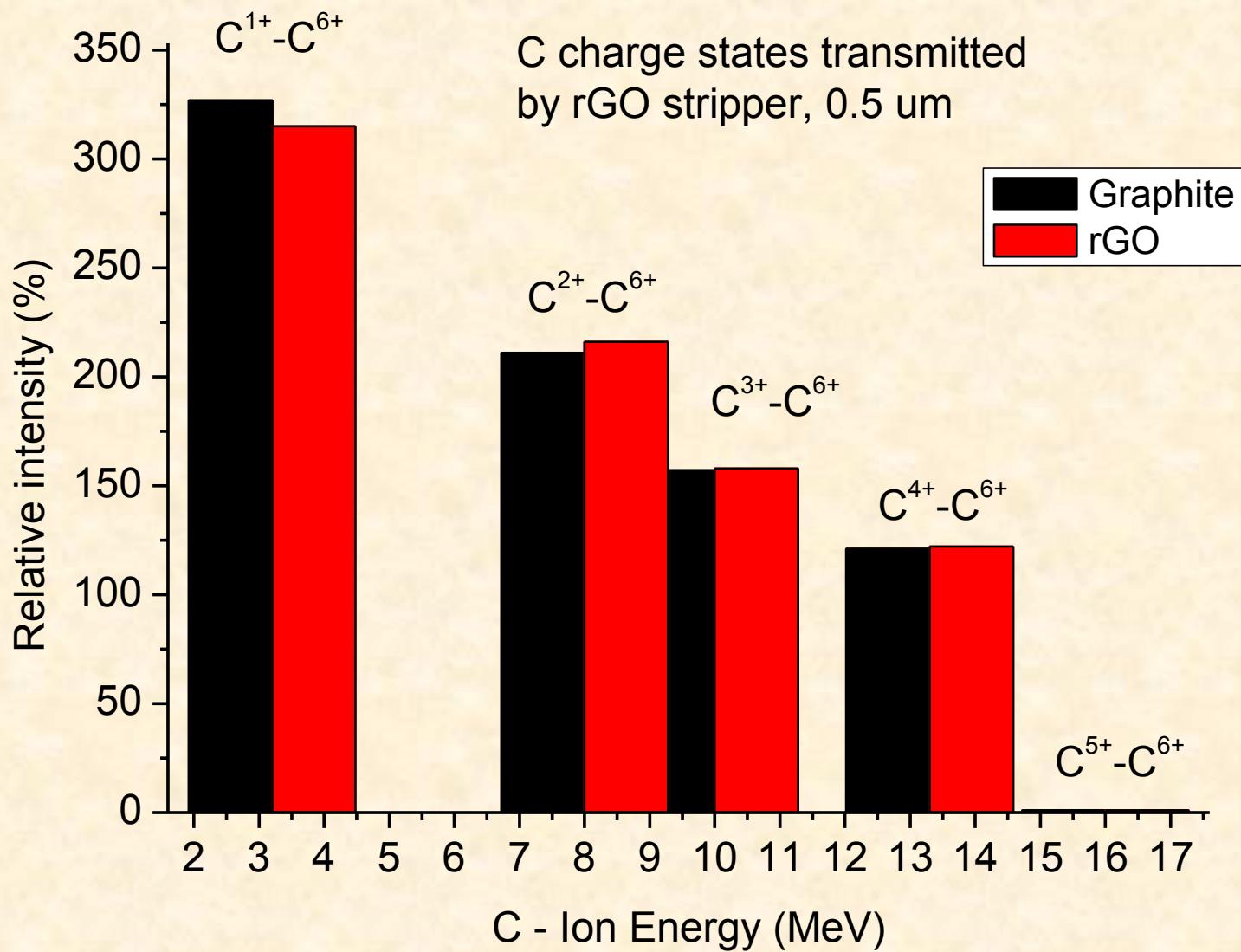
Gas stripper



# Principle of Stripper

- Carbon foils to extract positive protons by stripping two electrons from accelerated negative protons.
- Therefore a good quality of carbon foil is necessary to extract proton beam stable for a long time.
- The lifetime of stripping foils is limited by several factors- extracting currents, the foil thickness, the repetition rate





# Ionization potentials of the projectile atoms C atoms

## C - ATOMS

At. Num.	Sp. Name.	Ion Charge	El. name	Isoel. Seq.	Ground Shells	Ground Level	Ionized Level	Ionization Energy (eV)	Uncertainty (eV)	References
6	C I	0	Carbon	C	$1s^2 2s^2 2p^2$	${}^3P_0$	$2s^2 2p \ {}^2P^o_{1/2}$	11.2602880	0.0000011	<a href="#">L20057</a>
6	C II	+1	Carbon	B	$1s^2 2s^2 2p$	${}^2P^o_{1/2}$	$2s^2 \ {}^1S_0$	24.383154	0.000016	<a href="#">c190</a>
6	C III	+2	Carbon	Be	$1s^2 2s^2$	${}^1S_0$	$2s \ {}^2S_{1/2}$	47.88778	0.00025	<a href="#">L876c191</a>
6	C IV	+3	Carbon	Li	$1s^2 2s$	${}^2S_{1/2}$	$1s^2 \ {}^1S_0$	64.49352	0.00019	<a href="#">L11667</a>
6	C V	+4	Carbon	He	$1s^2$	${}^1S_0$	$1s \ {}^2S_{1/2}$	[392.090515]	0.000025	<a href="#">L10054</a>
6	C VI	+5	Carbon	H	1s	${}^2S_{1/2}$		(489.993194)	0.000007	<a href="#">L7188</a>

## O - ATOMS

At. Num.	Sp. Name.	Ion Charge	El. name	Isoel. Seq.	Ground Shells	Ground Level	Ionized Level	Ionization Energy (eV)	Uncertainty (eV)	References
8	O I	0	Oxygen	O	$1s^2 2s^2 2p^4$	${}^3P_2$	$2p^3 \ {}^4S^o_{3/2}$	13.618055	0.000007	<a href="#">L74,L3760</a>
8	O II	+1	Oxygen	N	$1s^2 2s^2 2p^3$	${}^4S^o_{3/2}$	$2p^2 \ {}^3P_0$	35.12112	0.00006	<a href="#">L11267,L10621</a>
8	O III	+2	Oxygen	C	$1s^2 2s^2 2p^2$	${}^3P_0$	$2p \ {}^2P^o_{1/2}$	[54.93554]	0.00012	<a href="#">L11770</a>
8	O IV	+3	Oxygen	B	$1s^2 2s^2 2p$	${}^2P^o_{1/2}$	$2s^2 \ {}^1S_0$	77.41350	0.00025	<a href="#">L648</a>
8	O V	+4	Oxygen	Be	$1s^2 2s^2$	${}^1S_0$	$2s \ {}^2S_{1/2}$	113.8990	0.0005	<a href="#">L7288</a>
8	O VI	+5	Oxygen	Li	$1s^2 2s$	${}^2S_{1/2}$	$1s^2 \ {}^1S_0$	[138.1189]	0.0021	<a href="#">L4713</a>
8	O VII	+6	Oxygen	He	$1s^2$	${}^1S_0$	$1s \ {}^2S_{1/2}$	[739.32682]	0.00006	<a href="#">L10054</a>
8	O VIII	+7	Oxygen	H	1s	${}^2S_{1/2}$		(871.40988)	0.00003	<a href="#">L7188</a>

# Graphene-based materials: Properties (rGO)

## ➤ Electrical

- Semiconductor with both holes and electrons as charge carriers
- Very high electrical conductivity (depending on the quality of graphene oxide)

## ➤ Mechanical

- Young's modulus ~ 260 GPa

## ➤ Optical

- Transmittance ~ 85% (IR); ~ 5% (Visible);

Metallic color

## ➤ Thermal

- Conductivity Above 600 W/(m K) (in plane)

## ➤ High Specific Surface Area

- Theoretically ~ 500 m<sup>2</sup>.g<sup>-1</sup>

## ➤ Low density

GO: ~ 1.8 g/cm<sup>3</sup>

